Figure 1

[illegible]	[illegible]	[illegible]	[illegible]
Valette S.,1987	Unknown	P doping	Not specified
Valette S.,1988	**Unknown**	**P doping**	**400°C**
Grand G., 1990	Unknown	P doping	1000°C
Liu K., 1995	Unknown	Content in Si, P	Not specified
Ojha S., 1998	Unknown	Ge, B, or P doping	Not specified
Canning J., 1998	Unknown	Ge doping	Not specified
Bulla D., 1998	TEOS	TEOS	Not specified
Johnson C., 1998	**$SiH_4 + O_2$**	**Si ion Implantation**	**400°C**
Boswell R. W., 1997	$SiH_4 + O_2$	SiH_4/O_2 flow ratio	1000°C
Bazylenko M. V., 1995	$SiH_4 + O_2 + CF_4$	$(SiH_4+O_2)/CF_4$ flow ratio	Not specified
Bazylenko M. V., 1996	$SiH_4 + O_2 + CF_4$	$(SiH_4+O_2)/CF_4$ flow ratio	1000°C
Durandet A., 1996	**$SiH_4 + O_2 + CF_4$**	**$SiH_4/O_2/CF_4$ flow ratio**	**100°C**
Kapser K., 1991	$SiH_4 + N_2O$	SiH_4/N_2O flow ratio	1060°C
Lai Q., 1992	$SiH_4 + N_2O$	SiH_4/N_2O flow ratio	1100°C
Lai Q.,1993	$SiH_4 + N_2O$	SiH_4/N_2O flow ratio	1100°C
Pereyra I., 1997	**$SiH_4 + N_2O$**	**SiH_4/N_2O flow ratio**	**400°C**
Alayo M., 1998	$SiH_4 + N_2O$	SiH_4/N_2O flow ratio	1000°C
Kenyon T., 1997	$SiH_4 + N_2O + Ar$	$SiH_4/N_2O/Ar$ flow ratio	1000°C
Lam D. K. W., 1984	$SiH_4 + N_2O + NH_3$	$SiH_4/N_2O/NH_3$ flow ratio	Not specified
Bruno F., 1991	$SiH_4 + N_2O + NH_3$	$SiH_4/N_2O/NH_3$ flow ratio	1100°C
Yokohama S., 1995	$SiH_4 + N_2O + NH_3$	$SiH_4/N_2O/NH_3$ flow ratio	Not specified
Agnihotri O. P., 1997	**$SiH_4 + N_2O + NH_3$**	**$SiH_4/N_2O/NH_3$ flow ratio**	**700-900°C**
Germann R., 1999	$SiH_4 + N_2O + NH_3$	Unknown	1100°C
Offrein B., 1999	$SiH_4 + N_2O + NH_3$	Unknown	1150°C
Hoffmann M., 1995	$SiH_4 + N_2O + NH_3 + Ar$	$SiH_4/N_2O/NH_3/Ar$ flow ratio	Not specified
Hoffmann M., 1997	$SiH_4 + N_2O + NH_3 + Ar$	$SiH_4/N_2O/NH_3/Ar$ flow ratio	Not specified
Tu Y., 1995	$SiH_4 + N_2O + NH_3 + N_2$	$N_2O/(N_2O + NH_3)$ flow ratio	1050°C
Poenar D., 1997	$SiH_4 + N_2O + NH_3 + N_2$	$SiH_4/N_2O/NH_3/N_2$ flow ratio	850°C
Ridder R., 1998	$SiH_4 + N_2O + NH_3 + N_2$	$SiH_4/N_2O/NH_3/Ar$ flow ratio	1100°C
Worhoff K., 1999	$SiH_4 + N_2O + NH_3 + N_2$	$SiH_4/N_2O/NH_3/N_2$ flow ratio	1150°C
Bulat E.S., 1993	**$SiH_4 + N_2O + N_2 + O_2 + He + CF_4$**	**$SiH_4/(N_2O/N_2)/ O_2/CF_4$ flow ratio**	**425°C**
This Patent Application	**$SiH_4 + N_2O + PH_3 + N_2$**	**Patented Pending Method**	**650°C**

Figure 2

		HO-H	SiO-H	SiN-H	SiN-H	Si-H	Si=O	N=N	Si-O-Si	Si-O-Si	Si-ON	Si-OH	Si-O-Si	Si-O-Si
FTIR 1st mode (cm-1)	Min	3550	3470	3380	3300	2210	1800	1530	1080	1000	910	860	740	410
	Ave	3650	3510	3420	3380	2260	1875	1555	1180	1080	950	885	810	460
	Max	3750	3550	3460	3460	2310	1950	1580	1280	1160	990	910	880	510
1st mode (μm)	Min	2.817	2.882	2.959	3.030	4.525	5.556	6.536	9.259	10.000	10.989	11.628	13.514	24.390
	Ave	2.740	2.849	2.924	2.959	4.425	5.333	6.431	8.475	9.259	10.526	11.299	12.346	21.739
	Max	2.667	2.817	2.890	2.890	4.329	5.128	6.329	7.813	8.621	10.101	10.989	11.364	19.608
2nd mode (μm)	Min	**1.408**	**1.441**	**1.479**	**1.515**	2.262	2.778	3.268	4.630	5.000	5.495	5.814	6.757	12.195
	Ave	**1.370**	**1.425**	**1.462**	**1.479**	2.212	2.667	3.215	4.237	4.630	5.263	5.650	6.173	10.870
	Max	**1.333**	**1.408**	**1.445**	**1.445**	2.165	2.564	3.165	3.906	4.310	5.051	5.495	5.682	9.804
3rd mode (μm)	Min	0.939	0.961	0.986	1.010	**1.508**	1.852	2.179	3.086	3.333	3.663	3.876	4.505	8.130
	Ave	0.913	0.950	0.975	0.986	**1.475**	1.778	2.144	2.825	3.086	3.509	3.766	4.115	7.246
	Max	0.889	0.939	0.963	0.963	**1.443**	1.709	2.110	2.604	2.874	3.367	3.663	3.788	6.536
4th mode (μm)	Min	0.704	0.720	0.740	0.758	1.131	**1.389**	1.634	2.315	2.500	2.747	2.907	3.378	6.098
	Ave	0.685	0.712	0.731	0.740	1.106	**1.333**	1.608	2.119	2.315	2.632	2.825	3.086	5.435
	Max	0.667	0.704	0.723	0.723	1.082	1.282	1.582	1.953	2.155	2.525	2.747	2.841	4.902
5th mode (μm)	Min	0.563	0.576	0.592	0.606	0.905	1.111	**1.307**	1.852	2.000	2.198	2.326	2.703	4.878
	Ave	0.548	0.570	0.585	0.592	0.885	1.067	1.286	1.695	1.852	2.105	2.260	2.469	4.348
	Max	0.533	0.563	0.578	0.578	0.866	1.026	1.266	1.563	1.724	2.020	2.198	2.273	3.922
6th mode (μm)	Min	0.469	0.480	0.493	0.505	0.754	0.926	1.089	**1.543**	1.667	1.832	1.938	2.252	4.065
	Ave	0.457	0.475	0.487	0.493	0.737	0.889	1.072	**1.412**	**1.543**	1.754	1.883	2.058	3.623
	Max	0.444	0.469	0.482	0.482	0.722	0.855	1.055	**1.302**	**1.437**	1.684	1.832	1.894	3.268
7th mode (μm)	Min	0.402	0.412	0.423	0.433	0.646	0.794	0.934	**1.323**	**1.429**	1.570	1.661	1.931	3.484
	Ave	0.391	0.407	0.418	0.423	0.632	0.762	0.919	1.211	**1.323**	**1.504**	1.614	1.764	3.106
	Max	0.381	0.402	0.413	0.413	0.618	0.733	0.904	1.116	1.232	**1.443**	1.570	1.623	2.801
8th mode (μm)	Min	0.352	0.360	0.370	0.379	0.566	0.694	0.817	1.157	1.250	**1.374**	**1.453**	1.689	3.049
	Ave	0.342	0.356	0.365	0.370	0.553	0.667	0.804	1.059	1.157	**1.316**	**1.412**	**1.543**	2.717
	Max	0.333	0.352	0.361	0.361	0.541	0.641	0.791	0.977	1.078	1.263	**1.374**	**1.420**	2.451

Figure 3a

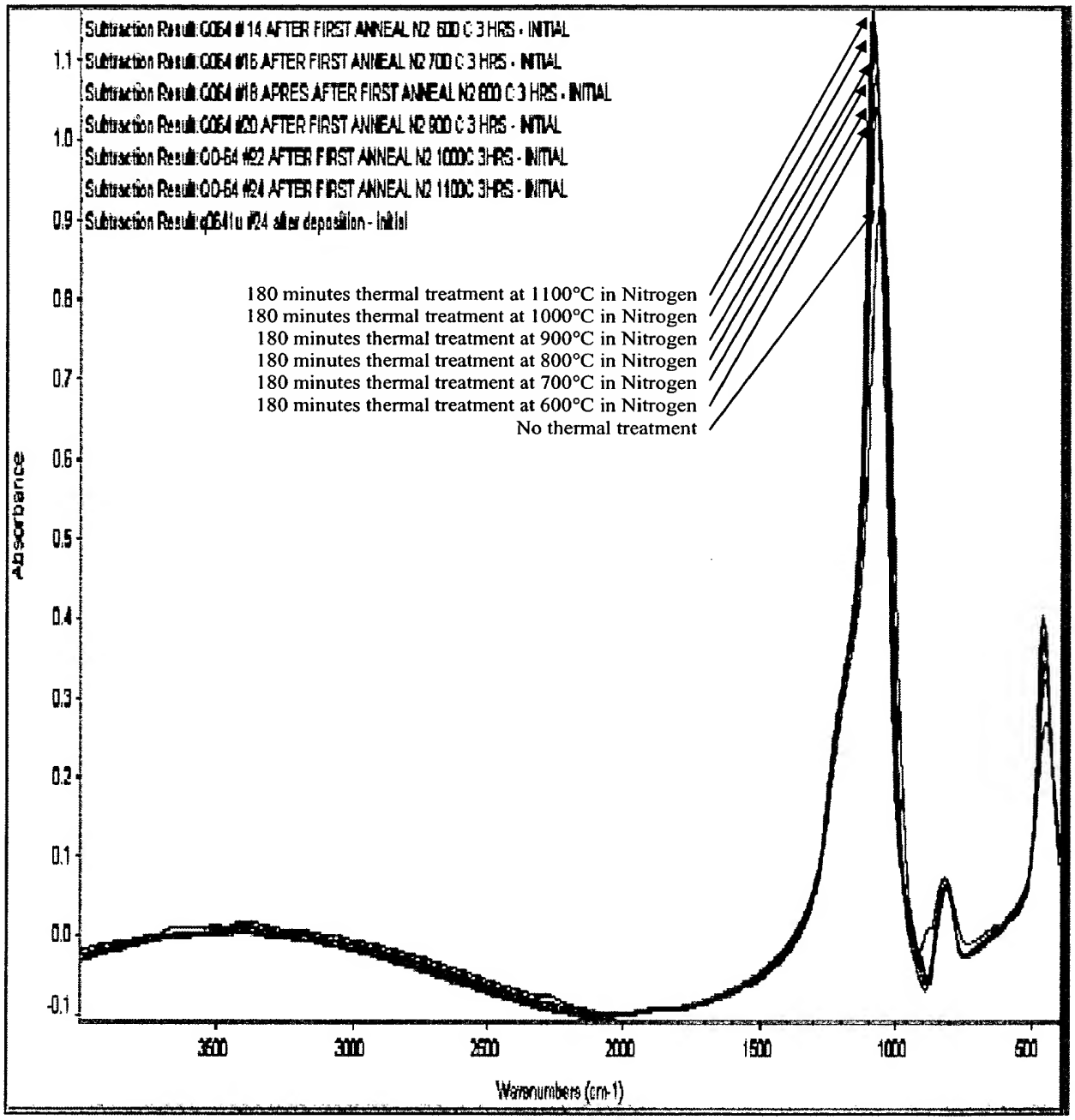

Subtraction Result:C064 #14 AFTER FIRST ANNEAL N2 600 C 3 HRS - INITIAL
Subtraction Result:C064 #16 AFTER FIRST ANNEAL N2 700 C 3 HRS - INITIAL
Subtraction Result:C064 #18 APRES AFTER FIRST ANNEAL N2 800 C 3 HRS - INITIAL
Subtraction Result:C064 #20 AFTER FIRST ANNEAL N2 900 C 3 HRS - INITIAL
Subtraction Result:CO-64 #22 AFTER FIRST ANNEAL N2 1000C 3HRS - INITIAL
Subtraction Result:CO-64 #24 AFTER FIRST ANNEAL N2 1100C 3HRS - INITIAL
Subtraction Result:c064 u #24 after deposition - initial
180 minutes thermal treatment at 1100°C in Nitrogen
180 minutes thermal treatment at 1000°C in Nitrogen
180 minutes thermal treatment at 900°C in Nitrogen
180 minutes thermal treatment at 800°C in Nitrogen
180 minutes thermal treatment at 700°C in Nitrogen
180 minutes thermal treatment at 600°C in Nitrogen
No thermal treatment
Absorbance
1.1
1.0
0.9
0.8
0.7
0.6
0.5
0.4
0.3
0.2
0.1
0.0
-0.1
3500
3000
2500
2000
1500
1000
500
Wavenumbers (cm-1)

Figure 3b

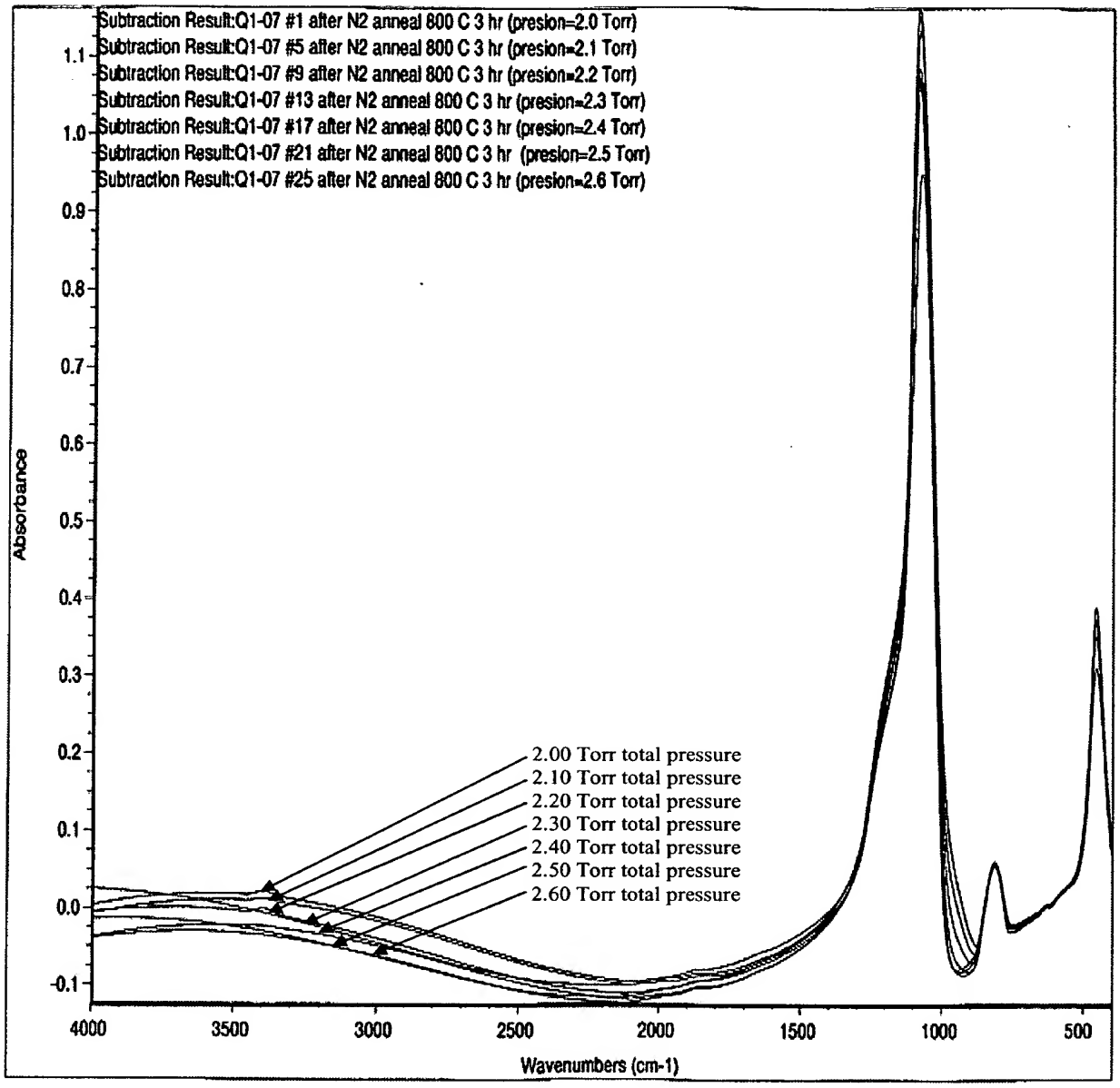

Subtraction Result:Q1-07 #1 after N2 anneal 800 C 3 hr (presion=2.0 Torr)
Subtraction Result:Q1-07 #5 after N2 anneal 800 C 3 hr (presion=2.1 Torr)
Subtraction Result:Q1-07 #9 after N2 anneal 800 C 3 hr (presion=2.2 Torr)
Subtraction Result:Q1-07 #13 after N2 anneal 800 C 3 hr (presion=2.3 Torr)
Subtraction Result:Q1-07 #17 after N2 anneal 800 C 3 hr (presion=2.4 Torr)
Subtraction Result:Q1-07 #21 after N2 anneal 800 C 3 hr (presion=2.5 Torr)
Subtraction Result:Q1-07 #25 after N2 anneal 800 C 3 hr (presion=2.6 Torr)
Absorbance
1.1
1.0
0.9
0.8
0.7
0.6
0.5
0.4
0.3
0.2
0.1
0.0
-0.1
2.00 Torr total pressure
2.10 Torr total pressure
2.20 Torr total pressure
2.30 Torr total pressure
2.40 Torr total pressure
2.50 Torr total pressure
2.60 Torr total pressure
4000
3500
3000
2500
2000
1500
1000
500
Wavenumbers (cm-1)

Figure 3c

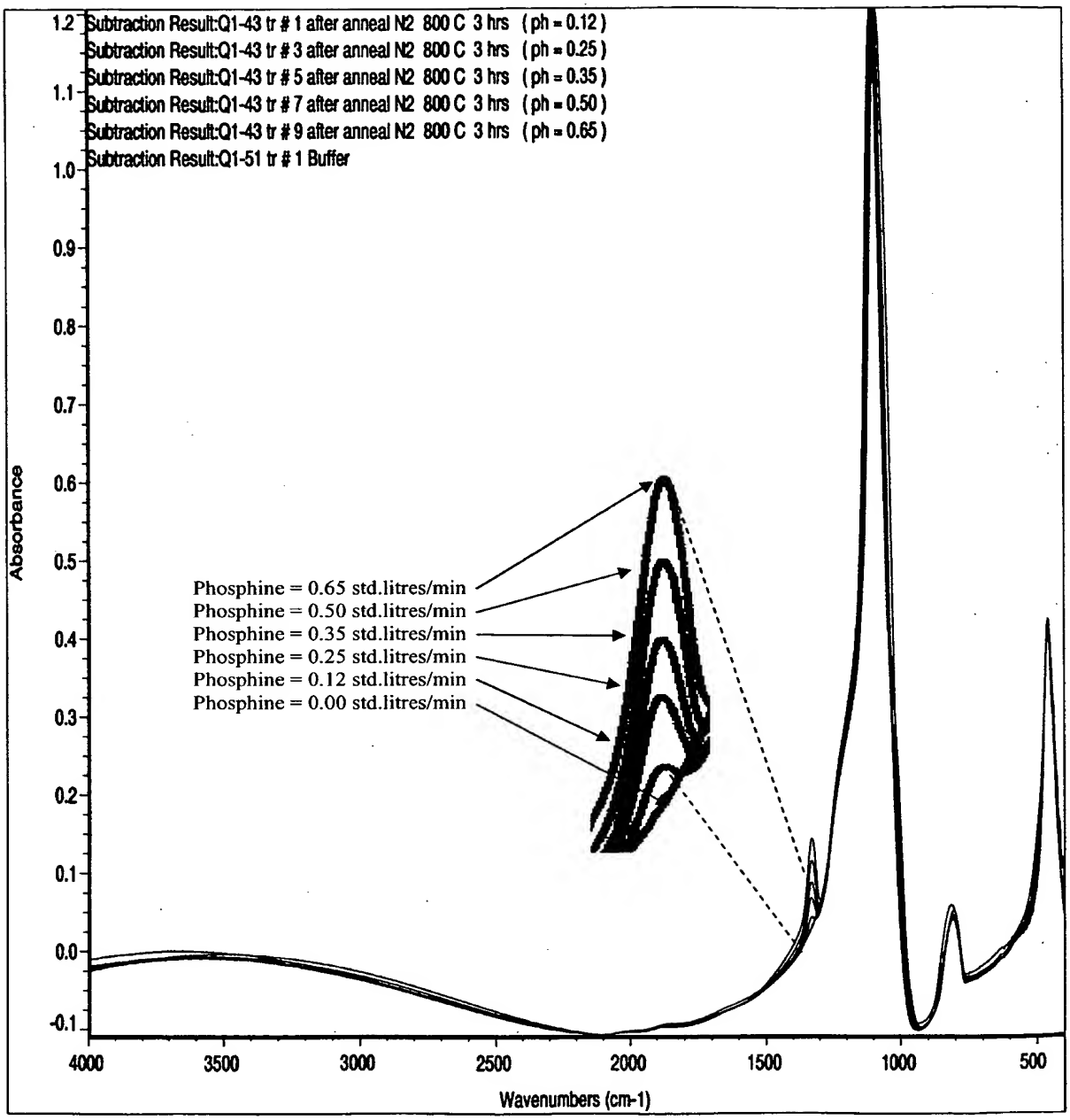

Subtraction Result:Q1-43 tr # 1 after anneal N2 800 C 3 hrs (ph = 0.12)
Subtraction Result:Q1-43 tr # 3 after anneal N2 800 C 3 hrs (ph = 0.25)
Subtraction Result:Q1-43 tr # 5 after anneal N2 800 C 3 hrs (ph = 0.35)
Subtraction Result:Q1-43 tr # 7 after anneal N2 800 C 3 hrs (ph = 0.50)
Subtraction Result:Q1-43 tr # 9 after anneal N2 800 C 3 hrs (ph = 0.65)
Subtraction Result:Q1-51 tr # 1 Buffer
Absorbance
1.2
1.1
1.0
0.9
0.8
0.7
0.6
0.5
0.4
0.3
0.2
0.1
0.0
-0.1
Phosphine = 0.65 std.litres/min
Phosphine = 0.50 std.litres/min
Phosphine = 0.35 std.litres/min
Phosphine = 0.25 std.litres/min
Phosphine = 0.12 std.litres/min
Phosphine = 0.00 std.litres/min
4000
3500
3000
2500
2000
1500
1000
500
Wavenumbers (cm-1)

Figure 3d

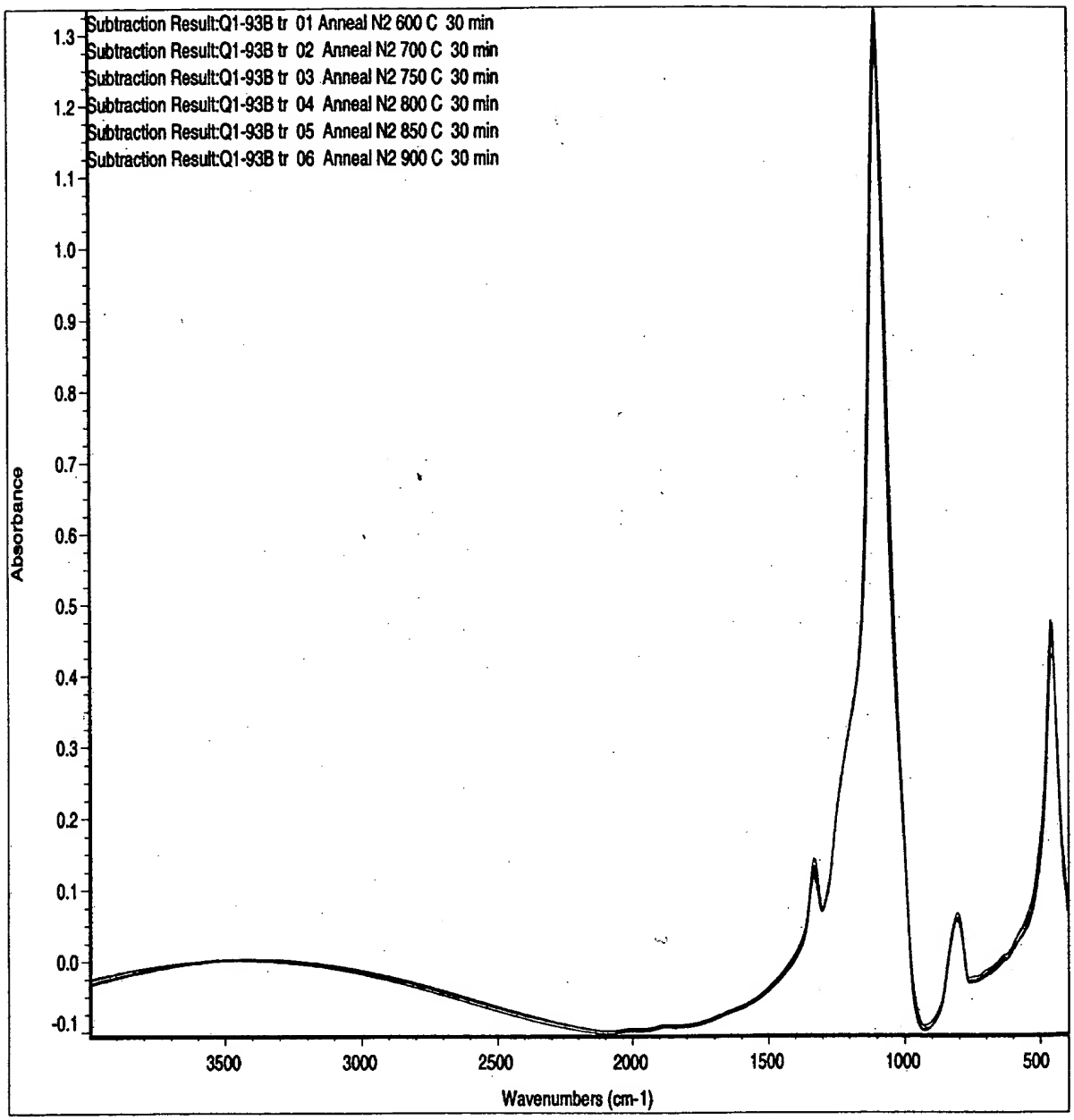

Subtraction Result:Q1-93B tr 01 Anneal N2 600 C 30 min
Subtraction Result:Q1-93B tr 02 Anneal N2 700 C 30 min
Subtraction Result:Q1-93B tr 03 Anneal N2 750 C 30 min
Subtraction Result:Q1-93B tr 04 Anneal N2 800 C 30 min
Subtraction Result:Q1-93B tr 05 Anneal N2 850 C 30 min
Subtraction Result:Q1-93B tr 06 Anneal N2 900 C 30 min
Absorbance
1.3
1.2
1.1
1.0
0.9
0.8
0.7
0.6
0.5
0.4
0.3
0.2
0.1
0.0
-0.1
3500
3000
2500
2000
1500
1000
500
Wavenumbers (cm-1)

Figure 4a

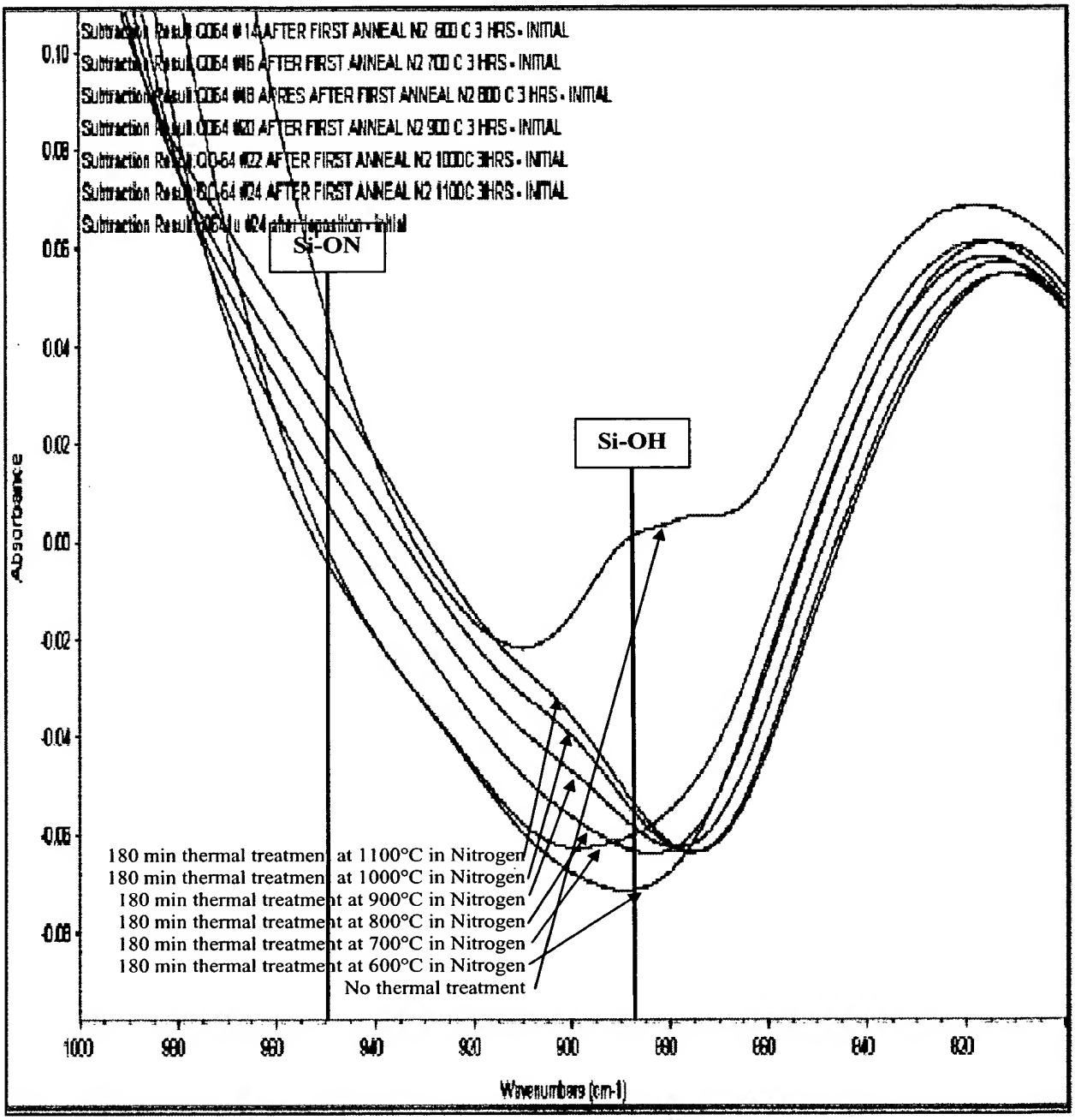

Si-ON
Si-OH
Absorbance
Wavenumbers (cm-1)
180 min thermal treatmen at 1100°C in Nitrogen
180 min thermal treatmen at 1000°C in Nitrogen
180 min thermal treatment at 900°C in Nitrogen
180 min thermal treatment at 800°C in Nitrogen
180 min thermal treatment at 700°C in Nitrogen
180 min thermal treatment at 600°C in Nitrogen
No thermal treatment

Figure 4b

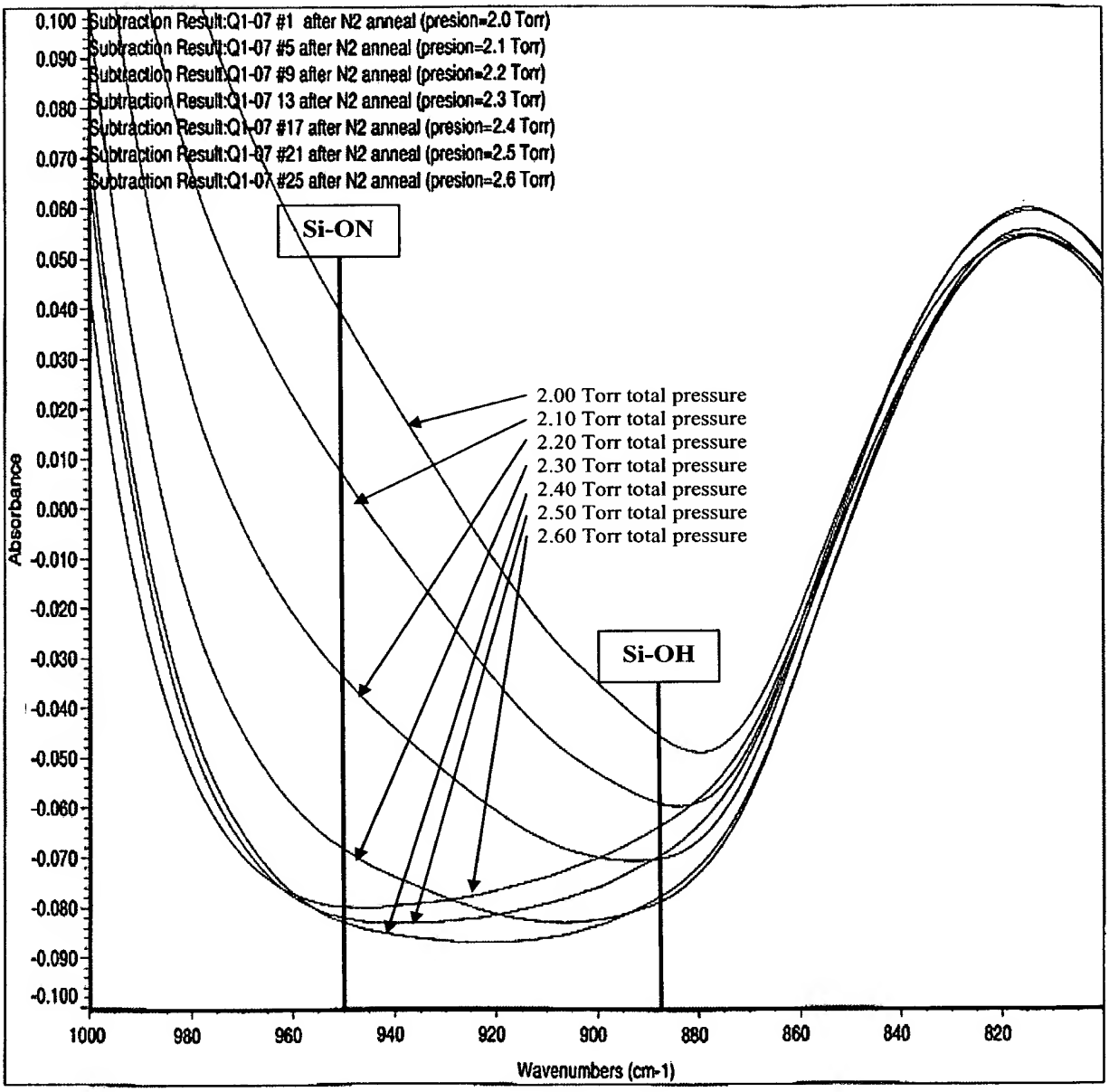

Subtraction Result:Q1-07 #1 after N2 anneal (presion=2.0 Torr)
Subtraction Result:Q1-07 #5 after N2 anneal (presion=2.1 Torr)
Subtraction Result:Q1-07 #9 after N2 anneal (presion=2.2 Torr)
Subtraction Result:Q1-07 13 after N2 anneal (presion=2.3 Torr)
Subtraction Result:Q1-07 #17 after N2 anneal (presion=2.4 Torr)
Subtraction Result:Q1-07 #21 after N2 anneal (presion=2.5 Torr)
Subtraction Result:Q1-07 #25 after N2 anneal (presion=2.6 Torr)
Si-ON
Si-OH
2.00 Torr total pressure
2.10 Torr total pressure
2.20 Torr total pressure
2.30 Torr total pressure
2.40 Torr total pressure
2.50 Torr total pressure
2.60 Torr total pressure
Absorbance
0.100
0.090
0.080
0.070
0.060
0.050
0.040
0.030
0.020
0.010
0.000
-0.010
-0.020
-0.030
-0.040
-0.050
-0.060
-0.070
-0.080
-0.090
-0.100
1000
980
960
940
920
900
880
860
840
820
Wavenumbers (cm-1)

Figure 4c

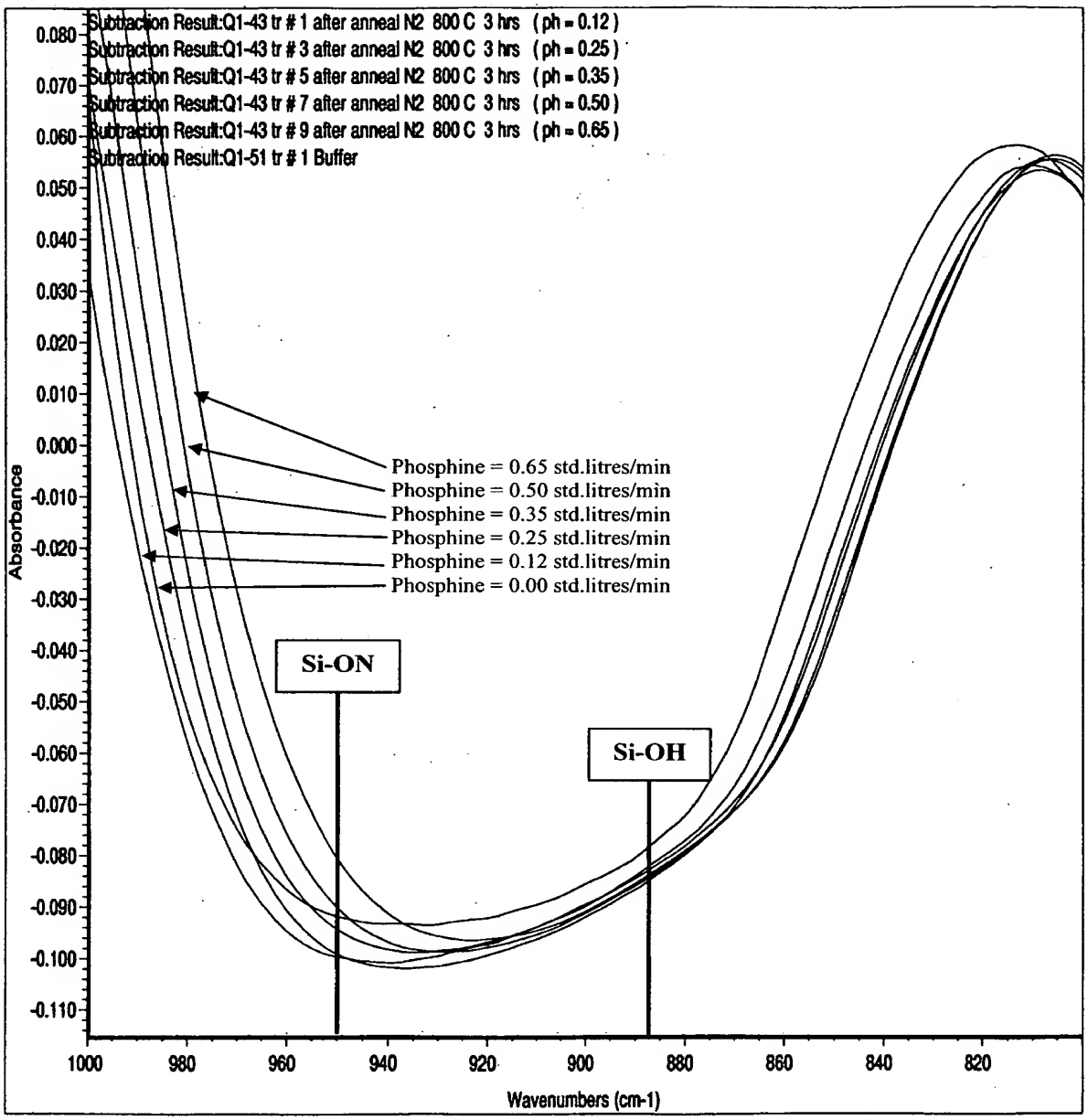

Subtraction Result:Q1-43 tr # 1 after anneal N2 800 C 3 hrs (ph = 0.12)
Subtraction Result:Q1-43 tr # 3 after anneal N2 800 C 3 hrs (ph = 0.25)
Subtraction Result:Q1-43 tr # 5 after anneal N2 800 C 3 hrs (ph = 0.35)
Subtraction Result:Q1-43 tr # 7 after anneal N2 800 C 3 hrs (ph = 0.50)
Subtraction Result:Q1-43 tr # 9 after anneal N2 800 C 3 hrs (ph = 0.65)
Subtraction Result:Q1-51 tr # 1 Buffer
Absorbance
0.080
0.070
0.060
0.050
0.040
0.030
0.020
0.010
0.000
-0.010
-0.020
-0.030
-0.040
-0.050
-0.060
-0.070
-0.080
-0.090
-0.100
-0.110
Phosphine = 0.65 std.litres/min
Phosphine = 0.50 std.litres/min
Phosphine = 0.35 std.litres/min
Phosphine = 0.25 std.litres/min
Phosphine = 0.12 std.litres/min
Phosphine = 0.00 std.litres/min
Si-ON
Si-OH
1000
980
960
940
920
900
880
860
840
820
Wavenumbers (cm-1)

Figure 4d

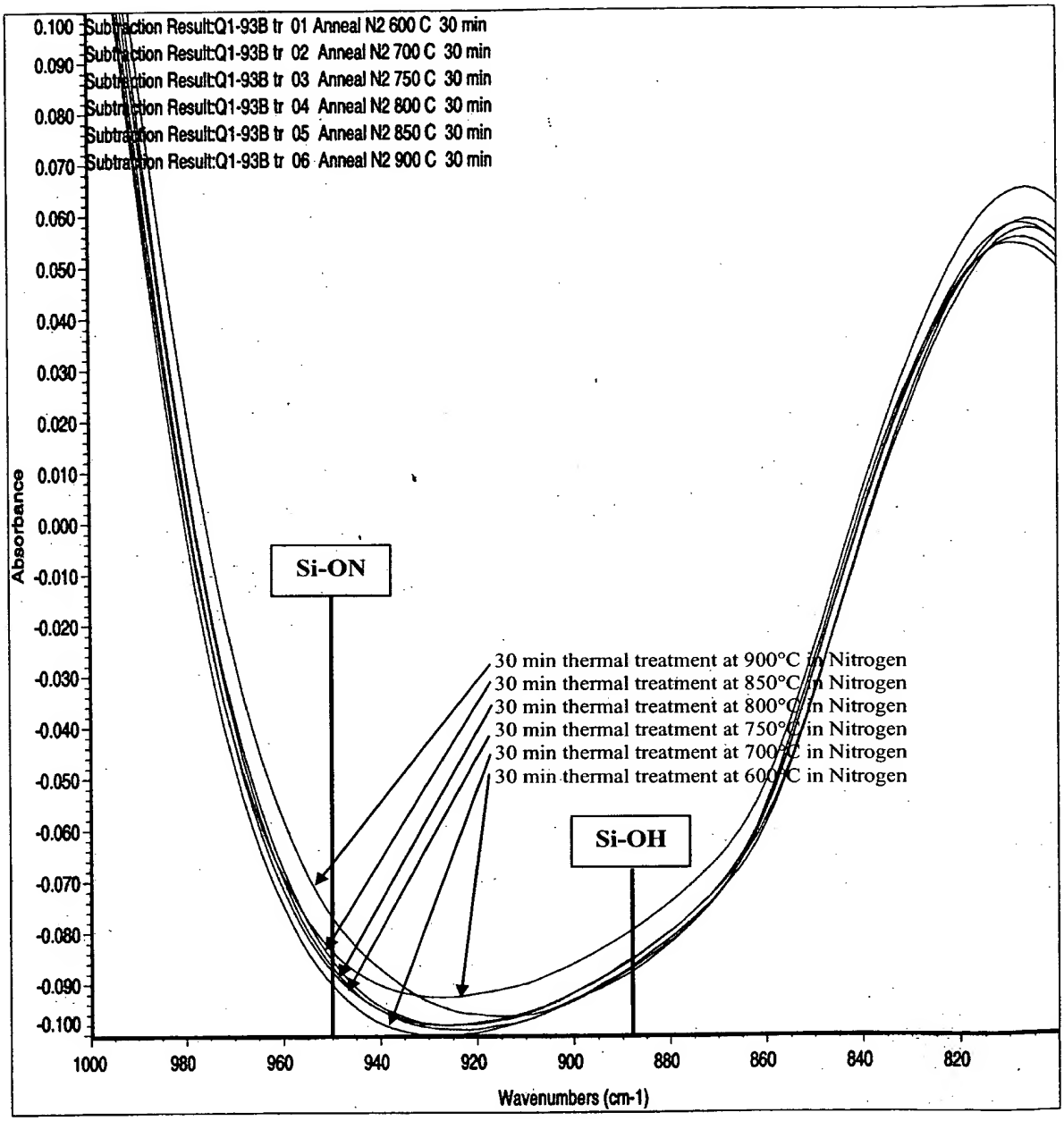

Subtraction Result:Q1-93B tr 01 Anneal N2 600 C 30 min
Subtraction Result:Q1-93B tr 02 Anneal N2 700 C 30 min
Subtraction Result:Q1-93B tr 03 Anneal N2 750 C 30 min
Subtraction Result:Q1-93B tr 04 Anneal N2 800 C 30 min
Subtraction Result:Q1-93B tr 05 Anneal N2 850 C 30 min
Subtraction Result:Q1-93B tr 06 Anneal N2 900 C 30 min
Absorbance
0.100
0.090
0.080
0.070
0.060
0.050
0.040
0.030
0.020
0.010
0.000
-0.010
-0.020
-0.030
-0.040
-0.050
-0.060
-0.070
-0.080
-0.090
-0.100
Si-ON
Si-OH
30 min thermal treatment at 900°C in Nitrogen
30 min thermal treatment at 850°C in Nitrogen
30 min thermal treatment at 800°C in Nitrogen
30 min thermal treatment at 750°C in Nitrogen
30 min thermal treatment at 700°C in Nitrogen
30 min thermal treatment at 600°C in Nitrogen
1000
980
960
940
920
900
880
860
840
820
Wavenumbers (cm-1)

Figure 5c

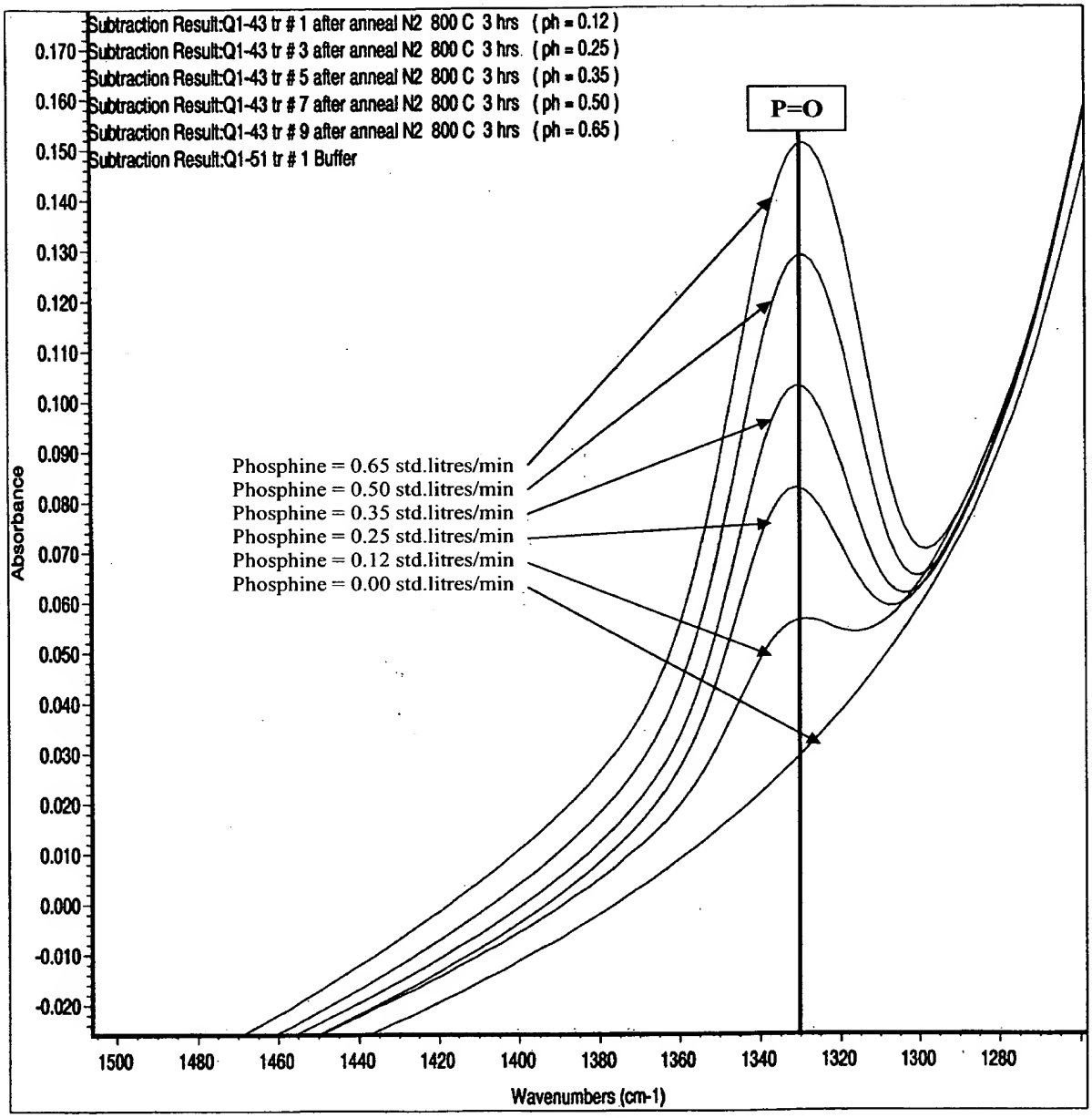

Subtraction Result:Q1-43 tr # 1 after anneal N2 800 C 3 hrs (ph = 0.12)
Subtraction Result:Q1-43 tr # 3 after anneal N2 800 C 3 hrs (ph = 0.25)
Subtraction Result:Q1-43 tr # 5 after anneal N2 800 C 3 hrs (ph = 0.35)
Subtraction Result:Q1-43 tr # 7 after anneal N2 800 C 3 hrs (ph = 0.50)
Subtraction Result:Q1-43 tr # 9 after anneal N2 800 C 3 hrs (ph = 0.65)
Subtraction Result:Q1-51 tr # 1 Buffer
P=O
Phosphine = 0.65 std.litres/min
Phosphine = 0.50 std.litres/min
Phosphine = 0.35 std.litres/min
Phosphine = 0.25 std.litres/min
Phosphine = 0.12 std.litres/min
Phosphine = 0.00 std.litres/min
Absorbance
0.170
0.160
0.150
0.140
0.130
0.120
0.110
0.100
0.090
0.080
0.070
0.060
0.050
0.040
0.030
0.020
0.010
0.000
-0.010
-0.020
1500
1480
1460
1440
1420
1400
1380
1360
1340
1320
1300
1280
Wavenumbers (cm-1)

Figure 5d

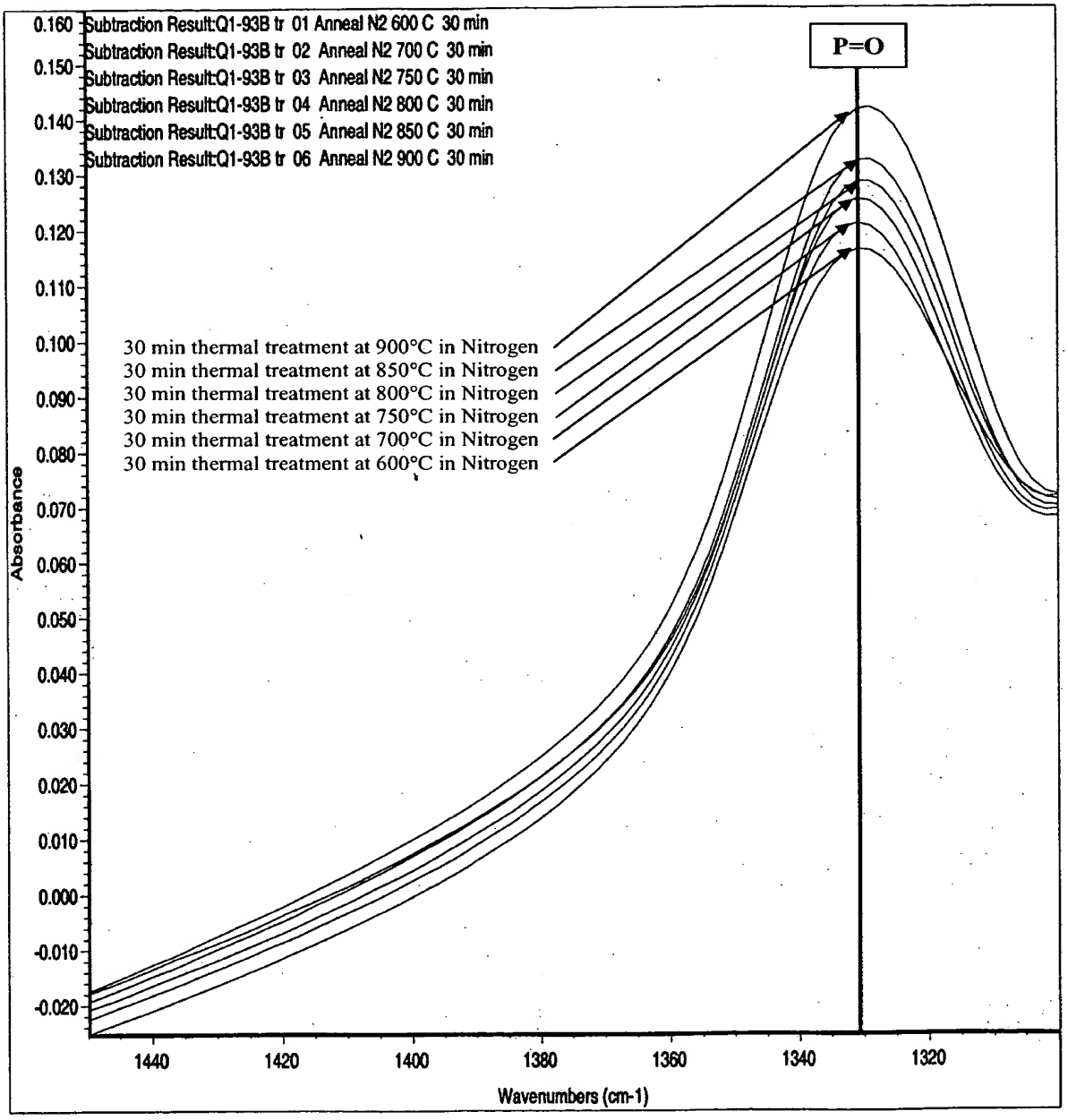

Subtraction Result:Q1-93B tr 01 Anneal N2 600 C 30 min
Subtraction Result:Q1-93B tr 02 Anneal N2 700 C 30 min
Subtraction Result:Q1-93B tr 03 Anneal N2 750 C 30 min
Subtraction Result:Q1-93B tr 04 Anneal N2 800 C 30 min
Subtraction Result:Q1-93B tr 05 Anneal N2 850 C 30 min
Subtraction Result:Q1-93B tr 06 Anneal N2 900 C 30 min
P=O
30 min thermal treatment at 900°C in Nitrogen
30 min thermal treatment at 850°C in Nitrogen
30 min thermal treatment at 800°C in Nitrogen
30 min thermal treatment at 750°C in Nitrogen
30 min thermal treatment at 700°C in Nitrogen
30 min thermal treatment at 600°C in Nitrogen
Absorbance
0.160
0.150
0.140
0.130
0.120
0.110
0.100
0.090
0.080
0.070
0.060
0.050
0.040
0.030
0.020
0.010
0.000
-0.010
-0.020
1440
1420
1400
1380
1360
1340
1320
Wavenumbers (cm-1)

Figure 6a

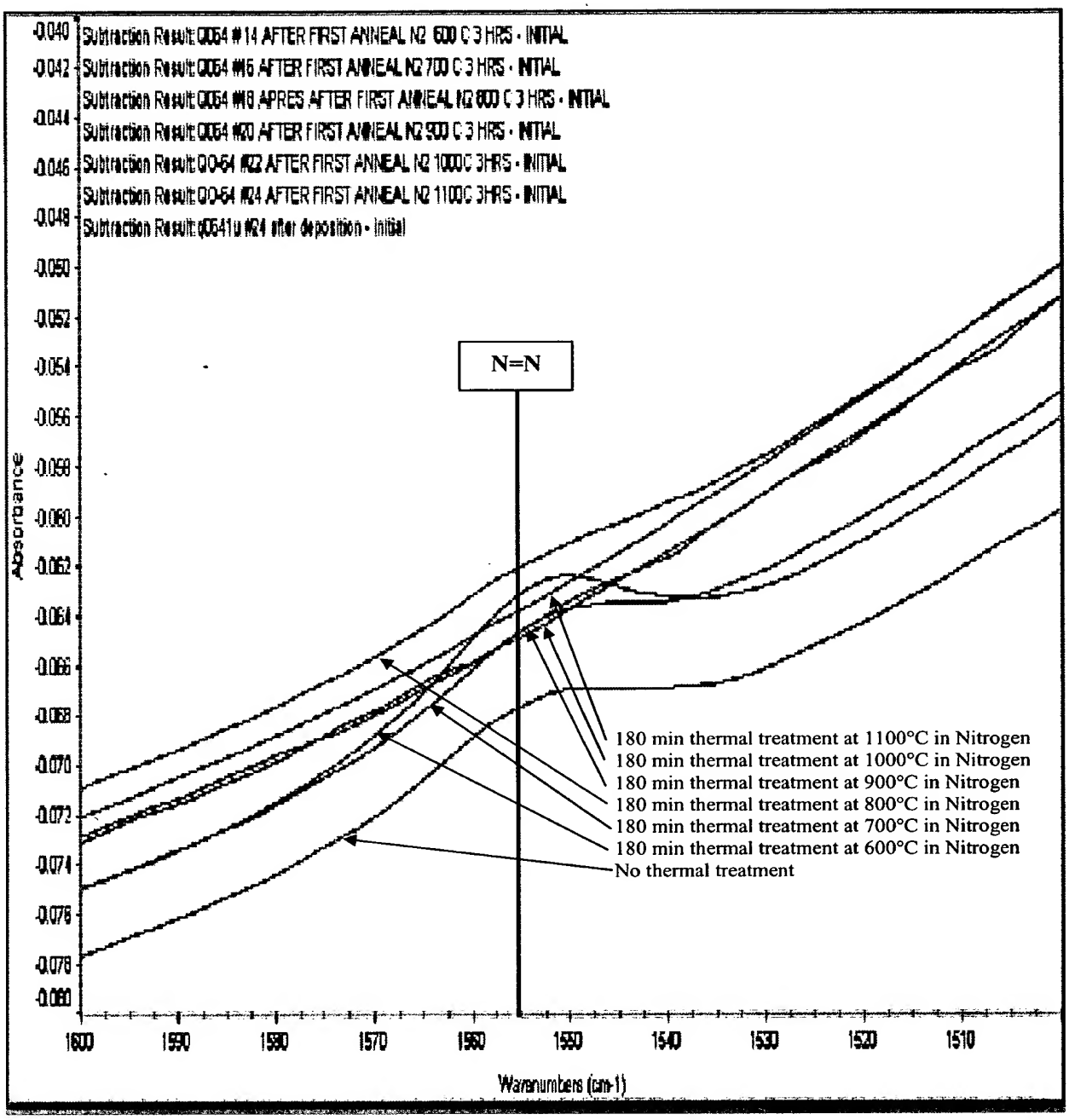

Subtraction Result:Q064 #14 AFTER FIRST ANNEAL N2 600 C 3 HRS - INITIAL
Subtraction Result:Q064 #16 AFTER FIRST ANNEAL N2 700 C 3 HRS - INITIAL
Subtraction Result:Q064 #18 APRES AFTER FIRST ANNEAL N2 800 C 3 HRS - INITIAL
Subtraction Result:Q064 #20 AFTER FIRST ANNEAL N2 900 C 3 HRS - INITIAL
Subtraction Result:QQ-64 #22 AFTER FIRST ANNEAL N2 1000C 3HRS - INITIAL
Subtraction Result:QQ-64 #24 AFTER FIRST ANNEAL N2 1100C 3HRS - INITIAL
Subtraction Result:Q041u #24 after deposition - initial
N=N
180 min thermal treatment at 1100°C in Nitrogen
180 min thermal treatment at 1000°C in Nitrogen
180 min thermal treatment at 900°C in Nitrogen
180 min thermal treatment at 800°C in Nitrogen
180 min thermal treatment at 700°C in Nitrogen
180 min thermal treatment at 600°C in Nitrogen
No thermal treatment
Absorbance
Wavenumbers (cm-1)

Figure 6b

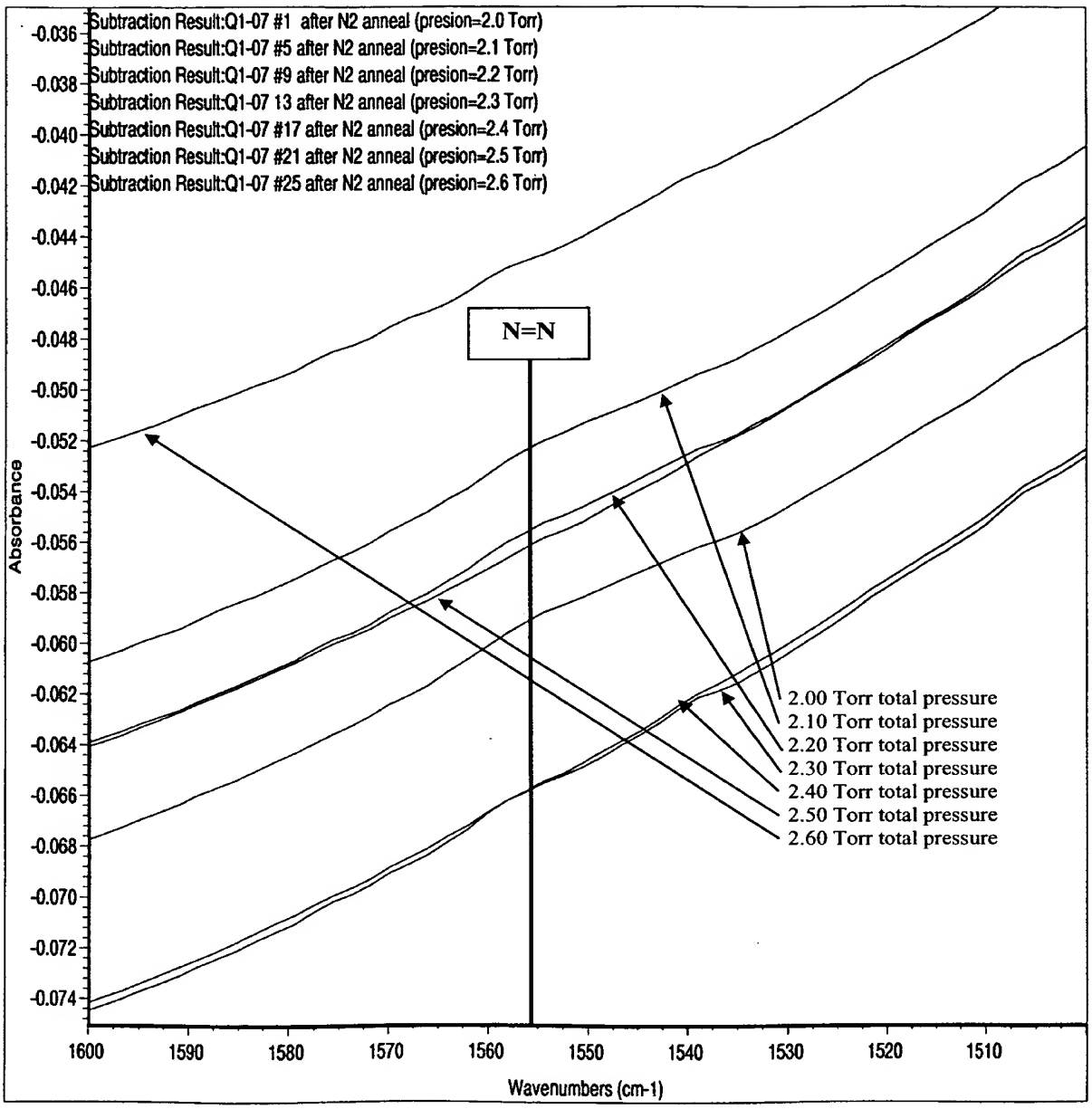

Subtraction Result:Q1-07 #1 after N2 anneal (presion=2.0 Torr)
Subtraction Result:Q1-07 #5 after N2 anneal (presion=2.1 Torr)
Subtraction Result:Q1-07 #9 after N2 anneal (presion=2.2 Torr)
Subtraction Result:Q1-07 13 after N2 anneal (presion=2.3 Torr)
Subtraction Result:Q1-07 #17 after N2 anneal (presion=2.4 Torr)
Subtraction Result:Q1-07 #21 after N2 anneal (presion=2.5 Torr)
Subtraction Result:Q1-07 #25 after N2 anneal (presion=2.6 Torr)
N=N
2.00 Torr total pressure
2.10 Torr total pressure
2.20 Torr total pressure
2.30 Torr total pressure
2.40 Torr total pressure
2.50 Torr total pressure
2.60 Torr total pressure
Absorbance
-0.036
-0.038
-0.040
-0.042
-0.044
-0.046
-0.048
-0.050
-0.052
-0.054
-0.056
-0.058
-0.060
-0.062
-0.064
-0.066
-0.068
-0.070
-0.072
-0.074
1600
1590
1580
1570
1560
1550
1540
1530
1520
1510
Wavenumbers (cm-1)

Figure 6c

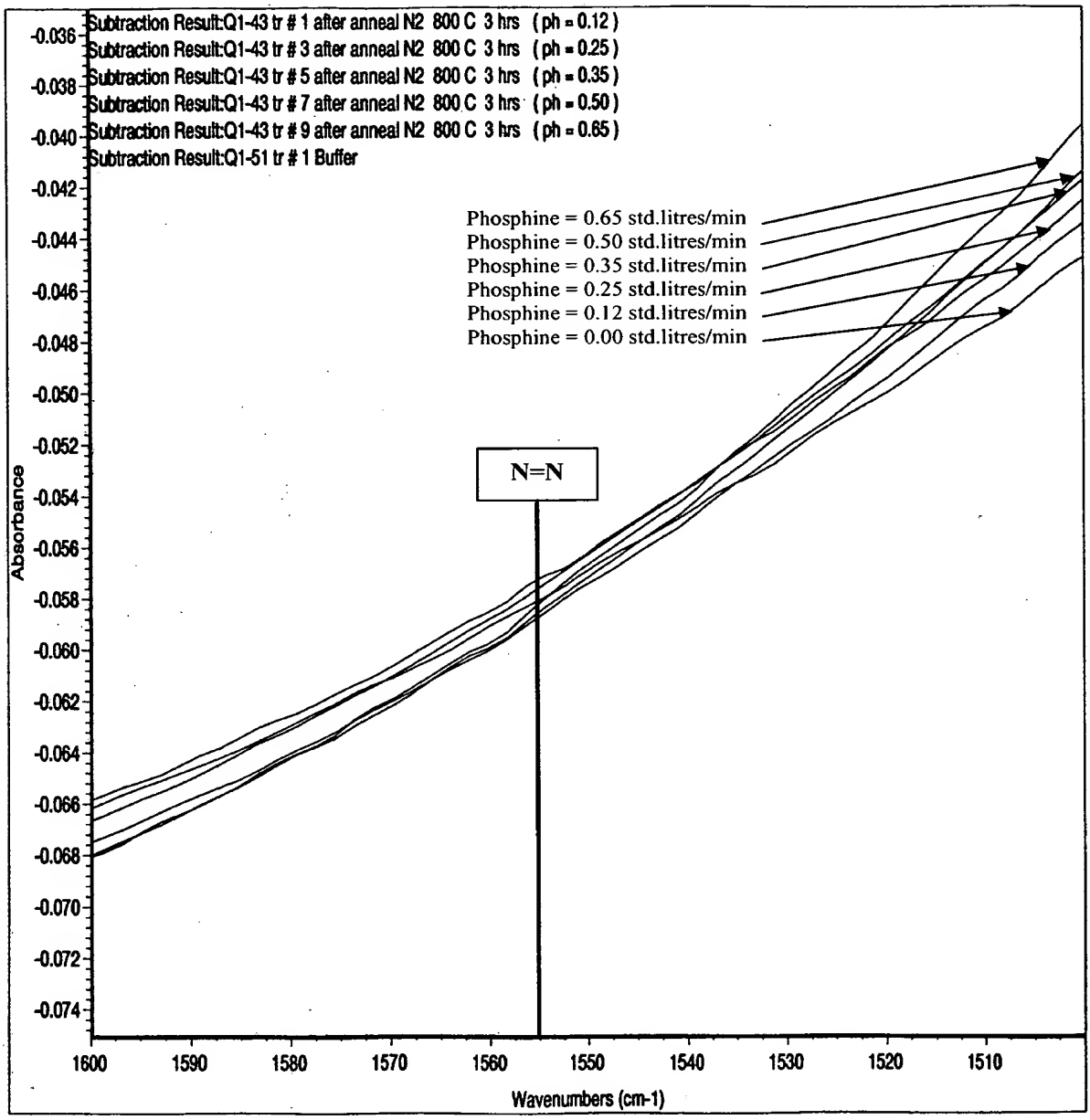

Subtraction Result:Q1-43 tr # 1 after anneal N2 800 C 3 hrs (ph = 0.12)
Subtraction Result:Q1-43 tr # 3 after anneal N2 800 C 3 hrs (ph = 0.25)
Subtraction Result:Q1-43 tr # 5 after anneal N2 800 C 3 hrs (ph = 0.35)
Subtraction Result:Q1-43 tr # 7 after anneal N2 800 C 3 hrs (ph = 0.50)
Subtraction Result:Q1-43 tr # 9 after anneal N2 800 C 3 hrs (ph = 0.65)
Subtraction Result:Q1-51 tr # 1 Buffer
Phosphine = 0.65 std.litres/min
Phosphine = 0.50 std.litres/min
Phosphine = 0.35 std.litres/min
Phosphine = 0.25 std.litres/min
Phosphine = 0.12 std.litres/min
Phosphine = 0.00 std.litres/min
N=N
Absorbance
-0.036
-0.038
-0.040
-0.042
-0.044
-0.046
-0.048
-0.050
-0.052
-0.054
-0.056
-0.058
-0.060
-0.062
-0.064
-0.066
-0.068
-0.070
-0.072
-0.074
1600
1590
1580
1570
1560
1550
1540
1530
1520
1510
Wavenumbers (cm-1)

Figure 6d

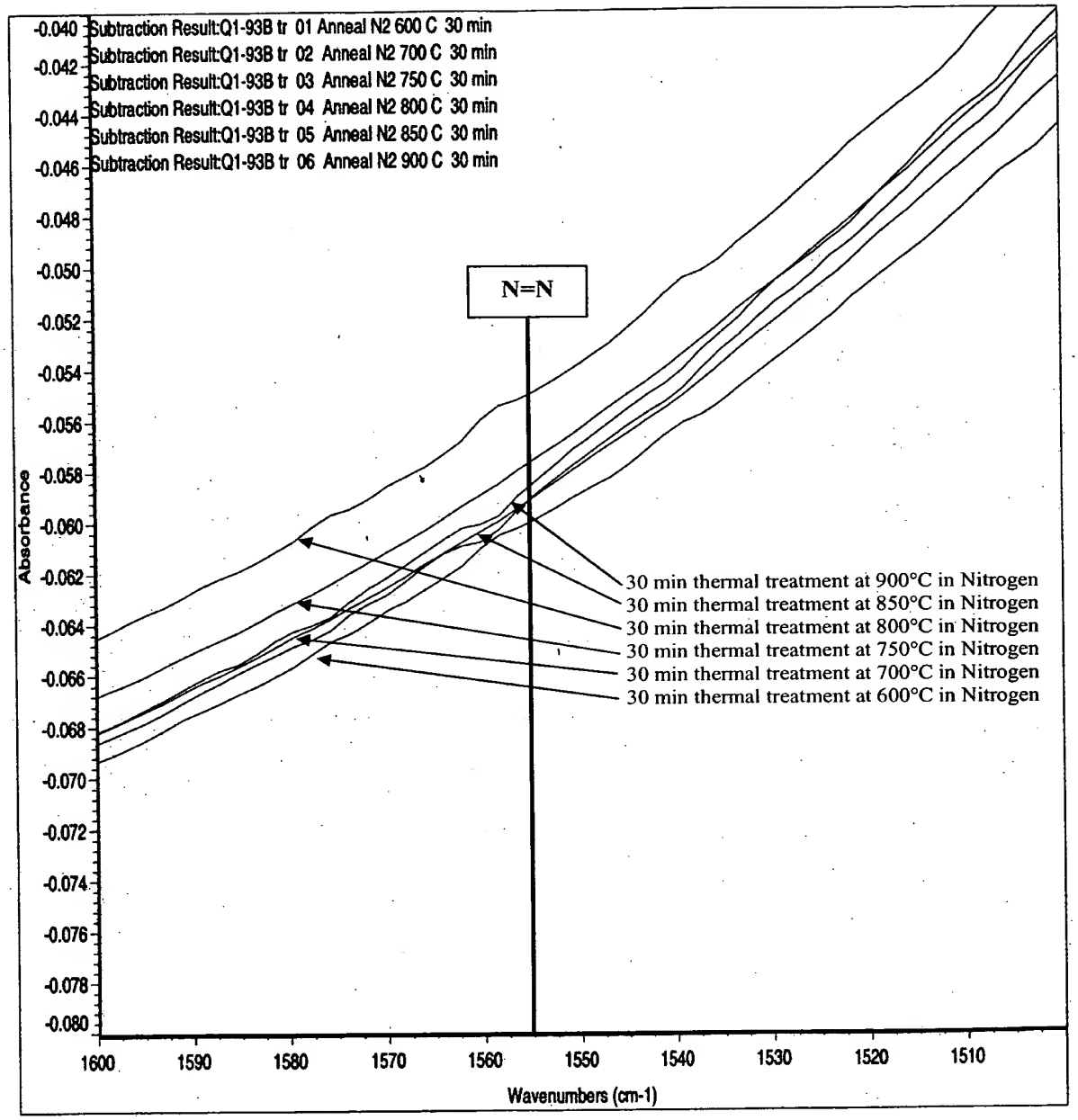

Subtraction Result:Q1-93B tr 01 Anneal N2 600 C 30 min
Subtraction Result:Q1-93B tr 02 Anneal N2 700 C 30 min
Subtraction Result:Q1-93B tr 03 Anneal N2 750 C 30 min
Subtraction Result:Q1-93B tr 04 Anneal N2 800 C 30 min
Subtraction Result:Q1-93B tr 05 Anneal N2 850 C 30 min
Subtraction Result:Q1-93B tr 06 Anneal N2 900 C 30 min
N=N
30 min thermal treatment at 900°C in Nitrogen
30 min thermal treatment at 850°C in Nitrogen
30 min thermal treatment at 800°C in Nitrogen
30 min thermal treatment at 750°C in Nitrogen
30 min thermal treatment at 700°C in Nitrogen
30 min thermal treatment at 600°C in Nitrogen
Absorbance
-0.040
-0.042
-0.044
-0.046
-0.048
-0.050
-0.052
-0.054
-0.056
-0.058
-0.060
-0.062
-0.064
-0.066
-0.068
-0.070
-0.072
-0.074
-0.076
-0.078
-0.080
1600
1590
1580
1570
1560
1550
1540
1530
1520
1510
Wavenumbers (cm-1)

Figure 7a

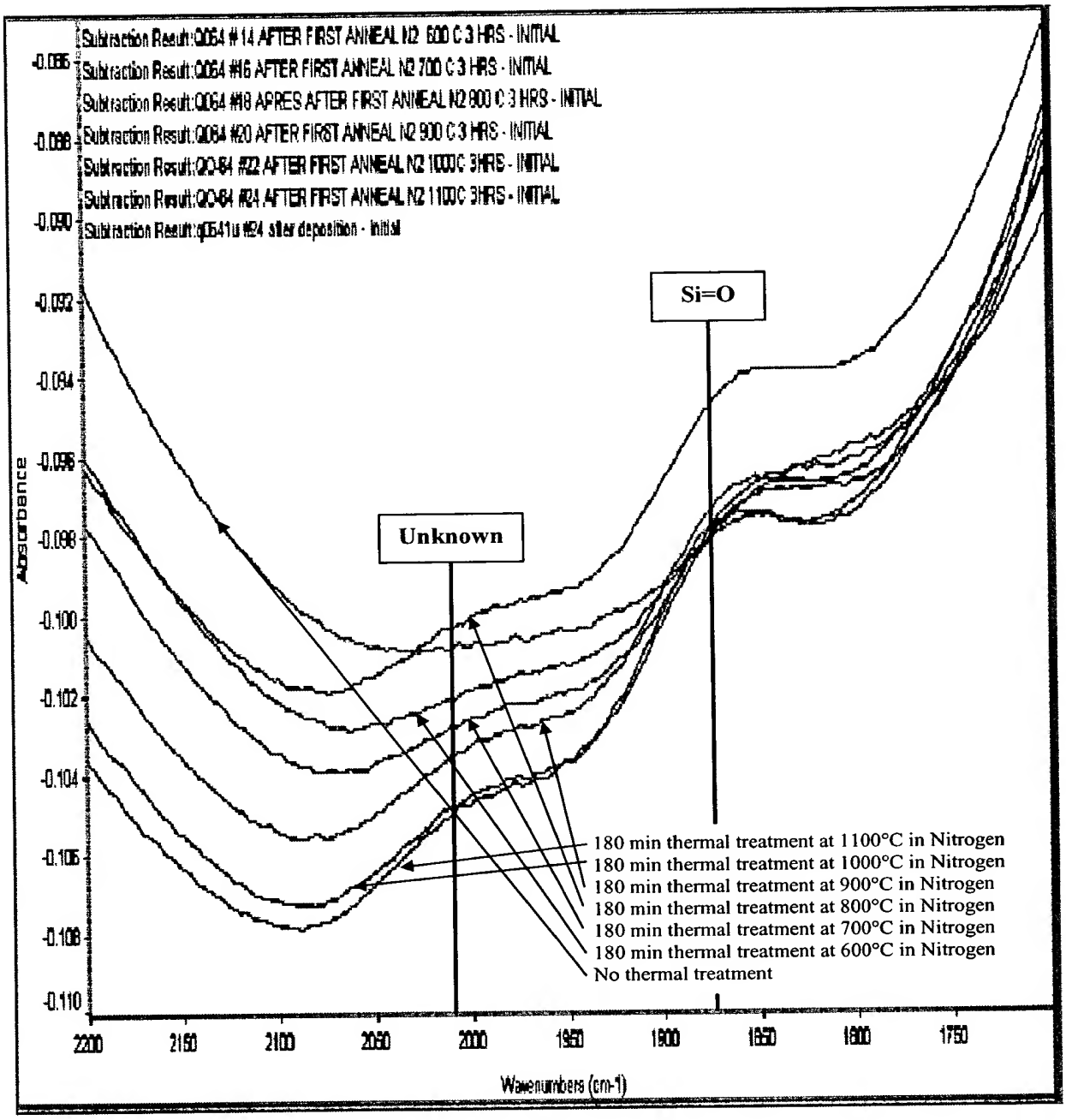

Subtraction Result:Q064 # 14 AFTER FIRST ANNEAL N2 600 C 3 HRS - INITIAL
Subtraction Result:Q064 #16 AFTER FIRST ANNEAL N2 700 C 3 HRS - INITIAL
Subtraction Result:Q064 #18 APRES AFTER FIRST ANNEAL N2 800 C 3 HRS - INITIAL
Subtraction Result:Q064 #20 AFTER FIRST ANNEAL N2 900 C 3 HRS - INITIAL
Subtraction Result:QQ-64 #22 AFTER FIRST ANNEAL N2 1000C 3HRS - INITIAL
Subtraction Result:QQ-64 #24 AFTER FIRST ANNEAL N2 1100C 3HRS - INITIAL
Subtraction Result:q0641u #24 after deposition - initial
Si=O
Unknown
180 min thermal treatment at 1100°C in Nitrogen
180 min thermal treatment at 1000°C in Nitrogen
180 min thermal treatment at 900°C in Nitrogen
180 min thermal treatment at 800°C in Nitrogen
180 min thermal treatment at 700°C in Nitrogen
180 min thermal treatment at 600°C in Nitrogen
No thermal treatment
Absorbance
-0.086
-0.088
-0.090
-0.092
-0.094
-0.096
-0.098
-0.100
-0.102
-0.104
-0.106
-0.108
-0.110
2200
2150
2100
2050
2000
1950
1900
1850
1800
1750
Wavenumbers (cm-1)

Figure 7b

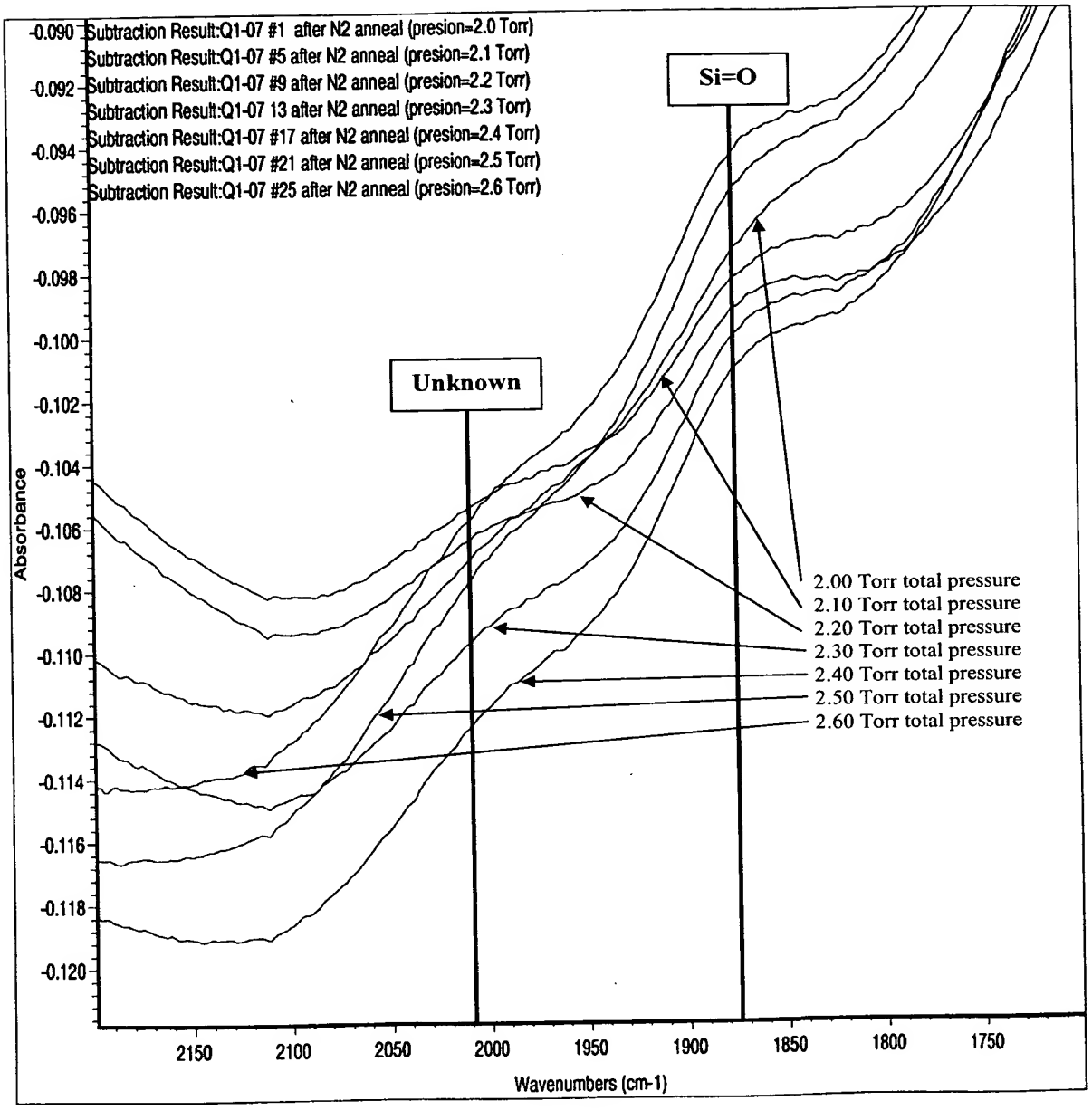

Subtraction Result:Q1-07 #1 after N2 anneal (presion=2.0 Torr)
Subtraction Result:Q1-07 #5 after N2 anneal (presion=2.1 Torr)
Subtraction Result:Q1-07 #9 after N2 anneal (presion=2.2 Torr)
Subtraction Result:Q1-07 13 after N2 anneal (presion=2.3 Torr)
Subtraction Result:Q1-07 #17 after N2 anneal (presion=2.4 Torr)
Subtraction Result:Q1-07 #21 after N2 anneal (presion=2.5 Torr)
Subtraction Result:Q1-07 #25 after N2 anneal (presion=2.6 Torr)
Si=O
Unknown
2.00 Torr total pressure
2.10 Torr total pressure
2.20 Torr total pressure
2.30 Torr total pressure
2.40 Torr total pressure
2.50 Torr total pressure
2.60 Torr total pressure
Absorbance
-0.090
-0.092
-0.094
-0.096
-0.098
-0.100
-0.102
-0.104
-0.106
-0.108
-0.110
-0.112
-0.114
-0.116
-0.118
-0.120
2150
2100
2050
2000
1950
1900
1850
1800
1750
Wavenumbers (cm-1)

Figure 7c

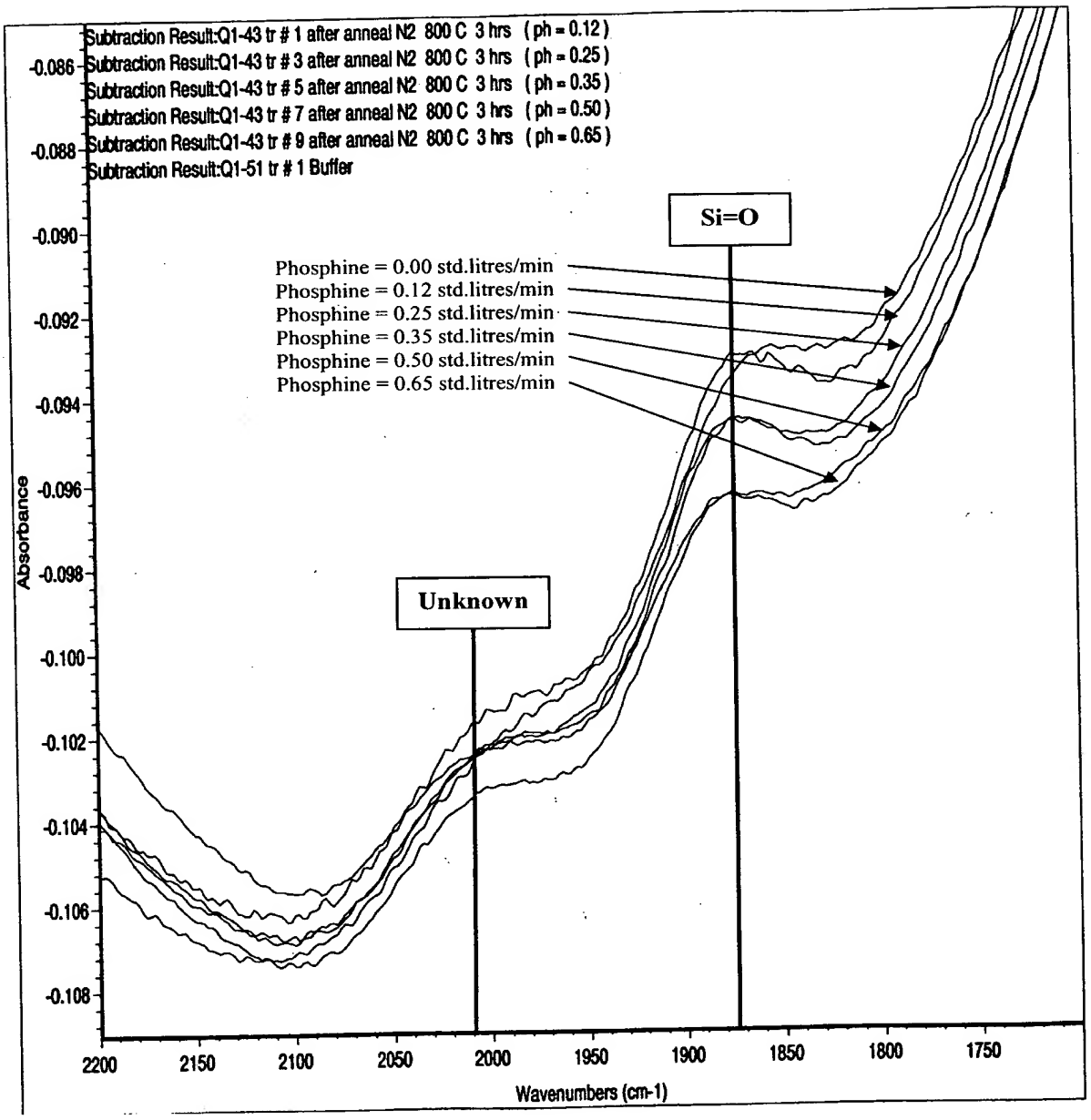

Subtraction Result:Q1-43 tr # 1 after anneal N2 800 C 3 hrs (ph = 0.12)
Subtraction Result:Q1-43 tr # 3 after anneal N2 800 C 3 hrs (ph = 0.25)
Subtraction Result:Q1-43 tr # 5 after anneal N2 800 C 3 hrs (ph = 0.35)
Subtraction Result:Q1-43 tr # 7 after anneal N2 800 C 3 hrs (ph = 0.50)
Subtraction Result:Q1-43 tr # 9 after anneal N2 800 C 3 hrs (ph = 0.65)
Subtraction Result:Q1-51 tr # 1 Buffer
Si=O
Phosphine = 0.00 std.litres/min
Phosphine = 0.12 std.litres/min
Phosphine = 0.25 std.litres/min
Phosphine = 0.35 std.litres/min
Phosphine = 0.50 std.litres/min
Phosphine = 0.65 std.litres/min
Unknown
Absorbance
-0.086
-0.088
-0.090
-0.092
-0.094
-0.096
-0.098
-0.100
-0.102
-0.104
-0.106
-0.108
2200
2150
2100
2050
2000
1950
1900
1850
1800
1750
Wavenumbers (cm-1)

Figure 7d

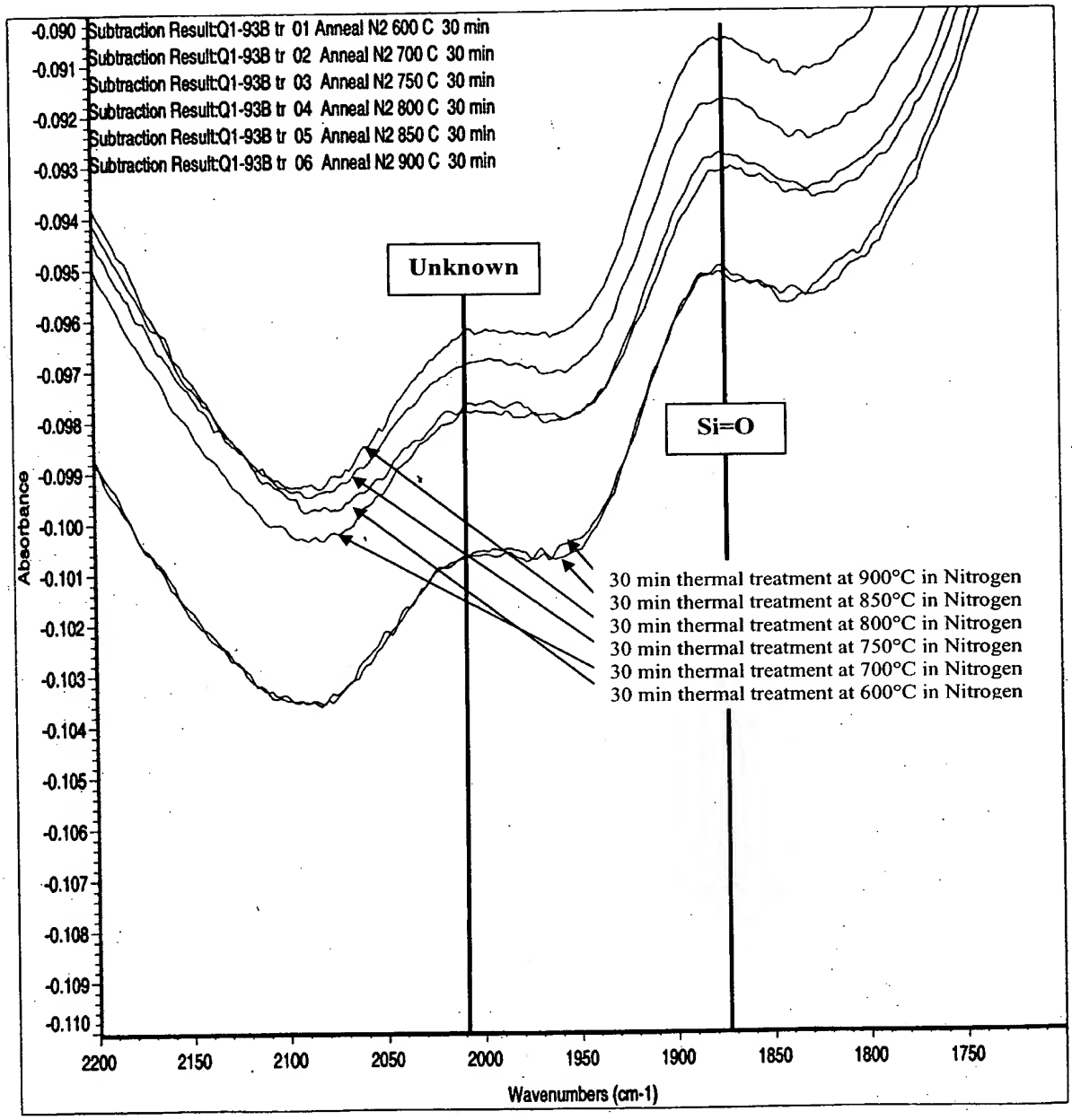

Subtraction Result:Q1-93B tr 01 Anneal N2 600 C 30 min
Subtraction Result:Q1-93B tr 02 Anneal N2 700 C 30 min
Subtraction Result:Q1-93B tr 03 Anneal N2 750 C 30 min
Subtraction Result:Q1-93B tr 04 Anneal N2 800 C 30 min
Subtraction Result:Q1-93B tr 05 Anneal N2 850 C 30 min
Subtraction Result:Q1-93B tr 06 Anneal N2 900 C 30 min
Unknown
Si=O
30 min thermal treatment at 900°C in Nitrogen
30 min thermal treatment at 850°C in Nitrogen
30 min thermal treatment at 800°C in Nitrogen
30 min thermal treatment at 750°C in Nitrogen
30 min thermal treatment at 700°C in Nitrogen
30 min thermal treatment at 600°C in Nitrogen
Absorbance
-0.090
-0.091
-0.092
-0.093
-0.094
-0.095
-0.096
-0.097
-0.098
-0.099
-0.100
-0.101
-0.102
-0.103
-0.104
-0.105
-0.106
-0.107
-0.108
-0.109
-0.110
2200
2150
2100
2050
2000
1950
1900
1850
1800
1750
Wavenumbers (cm-1)

Figure 8a

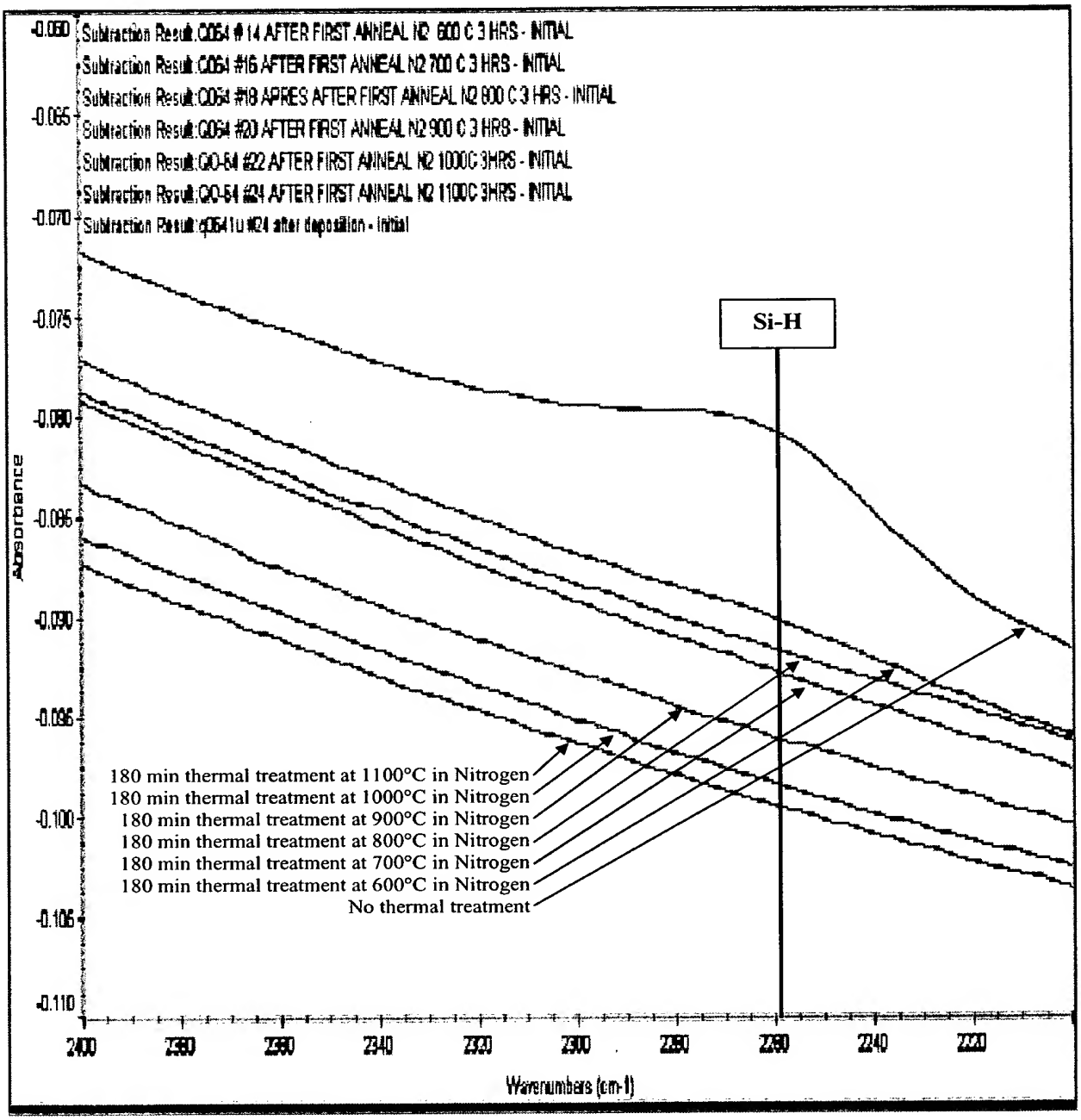

Subtraction Result:C064 #14 AFTER FIRST ANNEAL N2 600 C 3 HRS - INITIAL
Subtraction Result:C064 #16 AFTER FIRST ANNEAL N2 700 C 3 HRS - INITIAL
Subtraction Result:C064 #18 APRES AFTER FIRST ANNEAL N2 800 C 3 HRS - INITIAL
Subtraction Result:C064 #20 AFTER FIRST ANNEAL N2 900 C 3 HRS - INITIAL
Subtraction Result:CO-64 #22 AFTER FIRST ANNEAL N2 1000C 3HRS - INITIAL
Subtraction Result:CO-64 #24 AFTER FIRST ANNEAL N2 1100C 3HRS - INITIAL
Subtraction Result:c064 1u #24 after deposition - Initial
Si-H
180 min thermal treatment at 1100°C in Nitrogen
180 min thermal treatment at 1000°C in Nitrogen
180 min thermal treatment at 900°C in Nitrogen
180 min thermal treatment at 800°C in Nitrogen
180 min thermal treatment at 700°C in Nitrogen
180 min thermal treatment at 600°C in Nitrogen
No thermal treatment
Absorbance
-0.060
-0.065
-0.070
-0.075
-0.080
-0.085
-0.090
-0.095
-0.100
-0.105
-0.110
2400
2360
2320
2280
2240
2200
Wavenumbers (cm-1)

Figure 8b

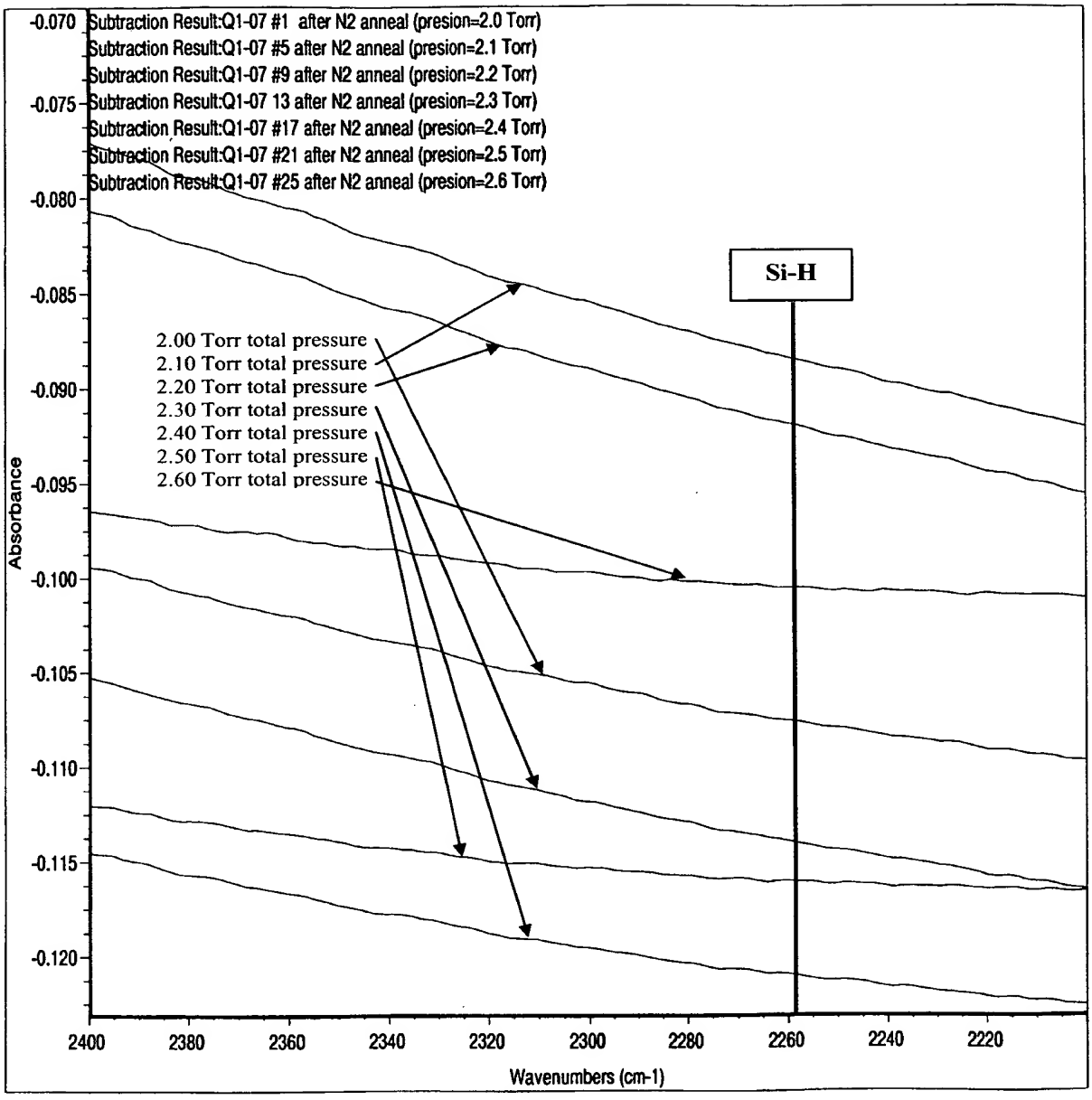

Subtraction Result:Q1-07 #1 after N2 anneal (presion=2.0 Torr)
Subtraction Result:Q1-07 #5 after N2 anneal (presion=2.1 Torr)
Subtraction Result:Q1-07 #9 after N2 anneal (presion=2.2 Torr)
Subtraction Result:Q1-07 13 after N2 anneal (presion=2.3 Torr)
Subtraction Result:Q1-07 #17 after N2 anneal (presion=2.4 Torr)
Subtraction Result:Q1-07 #21 after N2 anneal (presion=2.5 Torr)
Subtraction Result:Q1-07 #25 after N2 anneal (presion=2.6 Torr)
Si-H
2.00 Torr total pressure
2.10 Torr total pressure
2.20 Torr total pressure
2.30 Torr total pressure
2.40 Torr total pressure
2.50 Torr total pressure
2.60 Torr total pressure
Absorbance
-0.070
-0.075
-0.080
-0.085
-0.090
-0.095
-0.100
-0.105
-0.110
-0.115
-0.120
2400
2380
2360
2340
2320
2300
2280
2260
2240
2220
Wavenumbers (cm-1)

Figure 8c

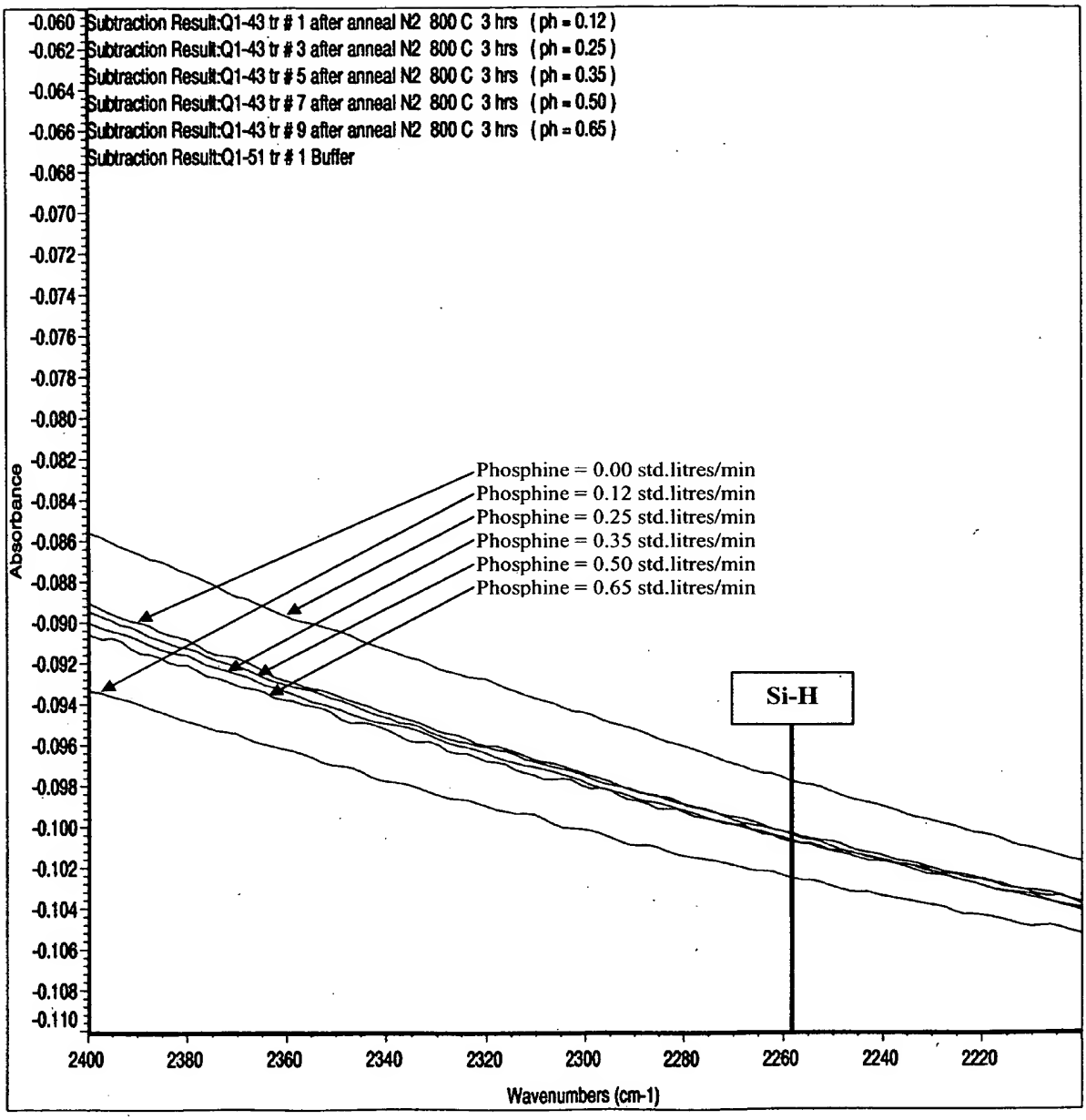

Subtraction Result:Q1-43 tr # 1 after anneal N2 800 C 3 hrs (ph = 0.12)
Subtraction Result:Q1-43 tr # 3 after anneal N2 800 C 3 hrs (ph = 0.25)
Subtraction Result:Q1-43 tr # 5 after anneal N2 800 C 3 hrs (ph = 0.35)
Subtraction Result:Q1-43 tr # 7 after anneal N2 800 C 3 hrs (ph = 0.50)
Subtraction Result:Q1-43 tr # 9 after anneal N2 800 C 3 hrs (ph = 0.65)
Subtraction Result:Q1-51 tr # 1 Buffer
Absorbance
-0.060
-0.062
-0.064
-0.066
-0.068
-0.070
-0.072
-0.074
-0.076
-0.078
-0.080
-0.082
-0.084
-0.086
-0.088
-0.090
-0.092
-0.094
-0.096
-0.098
-0.100
-0.102
-0.104
-0.106
-0.108
-0.110
Phosphine = 0.00 std.litres/min
Phosphine = 0.12 std.litres/min
Phosphine = 0.25 std.litres/min
Phosphine = 0.35 std.litres/min
Phosphine = 0.50 std.litres/min
Phosphine = 0.65 std.litres/min
Si-H
2400
2380
2360
2340
2320
2300
2280
2260
2240
2220
Wavenumbers (cm-1)

Figure 8d

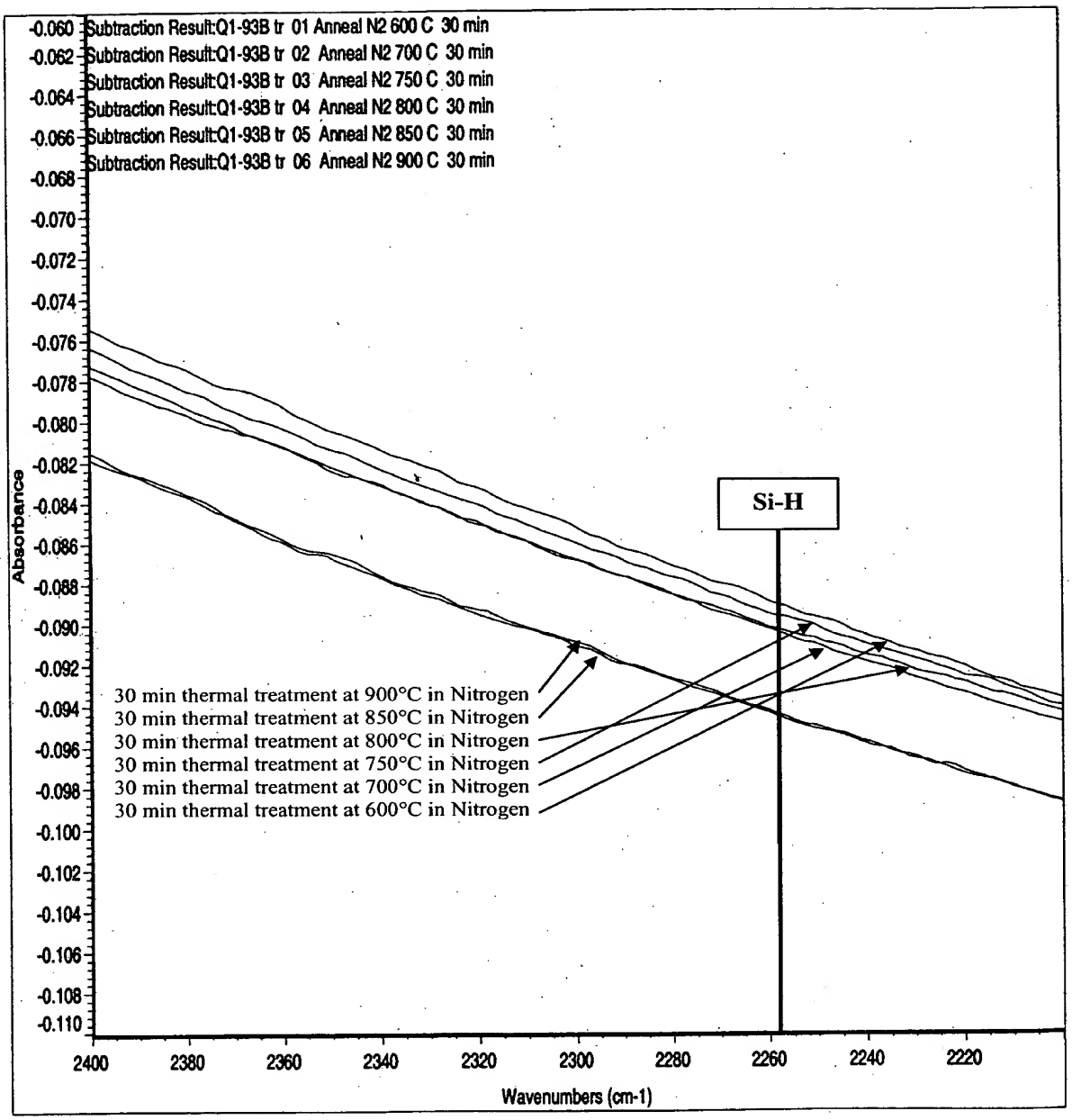

Subtraction Result:Q1-93B tr 01 Anneal N2 600 C 30 min
Subtraction Result:Q1-93B tr 02 Anneal N2 700 C 30 min
Subtraction Result:Q1-93B tr 03 Anneal N2 750 C 30 min
Subtraction Result:Q1-93B tr 04 Anneal N2 800 C 30 min
Subtraction Result:Q1-93B tr 05 Anneal N2 850 C 30 min
Subtraction Result:Q1-93B tr 06 Anneal N2 900 C 30 min
Absorbance
-0.060
-0.062
-0.064
-0.066
-0.068
-0.070
-0.072
-0.074
-0.076
-0.078
-0.080
-0.082
-0.084
-0.086
-0.088
-0.090
-0.092
-0.094
-0.096
-0.098
-0.100
-0.102
-0.104
-0.106
-0.108
-0.110
Si-H
30 min thermal treatment at 900°C in Nitrogen
30 min thermal treatment at 850°C in Nitrogen
30 min thermal treatment at 800°C in Nitrogen
30 min thermal treatment at 750°C in Nitrogen
30 min thermal treatment at 700°C in Nitrogen
30 min thermal treatment at 600°C in Nitrogen
2400
2380
2360
2340
2320
2300
2280
2260
2240
2220
Wavenumbers (cm-1)

Figure 9a

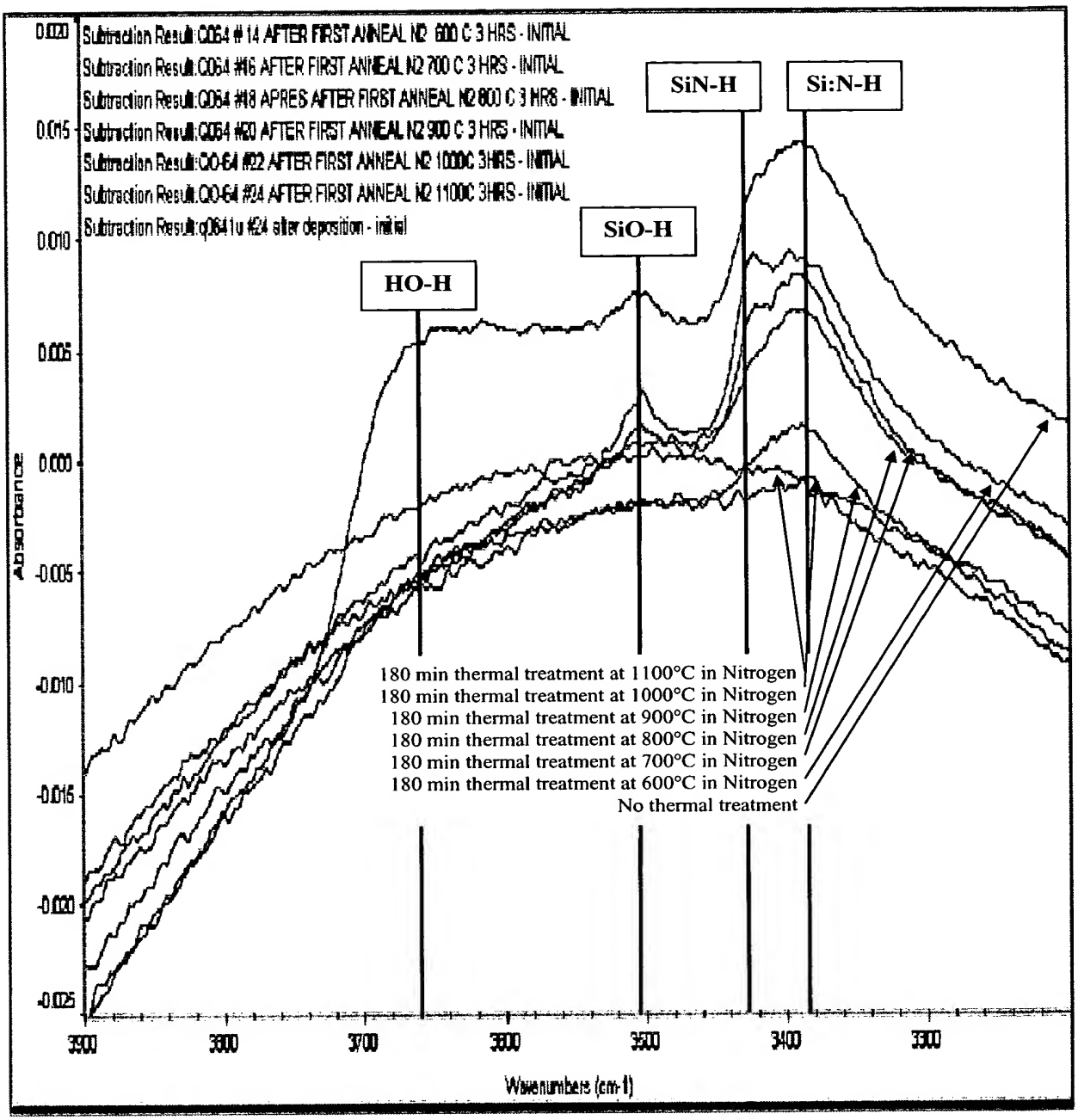

Subtraction Result:Q064 # 14 AFTER FIRST ANNEAL N2 600 C 3 HRS - INITIAL
Subtraction Result:Q064 #16 AFTER FIRST ANNEAL N2 700 C 3 HRS - INITIAL
Subtraction Result:Q064 #18 APRES AFTER FIRST ANNEAL N2 800 C 3 HRS - INITIAL
Subtraction Result:Q064 #20 AFTER FIRST ANNEAL N2 900 C 3 HRS - INITIAL
Subtraction Result:Q0-64 #22 AFTER FIRST ANNEAL N2 1000C 3HRS - INITIAL
Subtraction Result:Q0-64 #24 AFTER FIRST ANNEAL N2 1100C 3HRS - INITIAL
Subtraction Result:q064 1u #24 after deposition - initial
SiN-H
Si:N-H
SiO-H
HO-H
180 min thermal treatment at 1100°C in Nitrogen
180 min thermal treatment at 1000°C in Nitrogen
180 min thermal treatment at 900°C in Nitrogen
180 min thermal treatment at 800°C in Nitrogen
180 min thermal treatment at 700°C in Nitrogen
180 min thermal treatment at 600°C in Nitrogen
No thermal treatment
Absorbance
0.020
0.015
0.010
0.005
0.000
-0.005
-0.010
-0.015
-0.020
-0.025
3900
3800
3700
3600
3500
3400
3300
Wavenumbers (cm-1)

Figure 9b

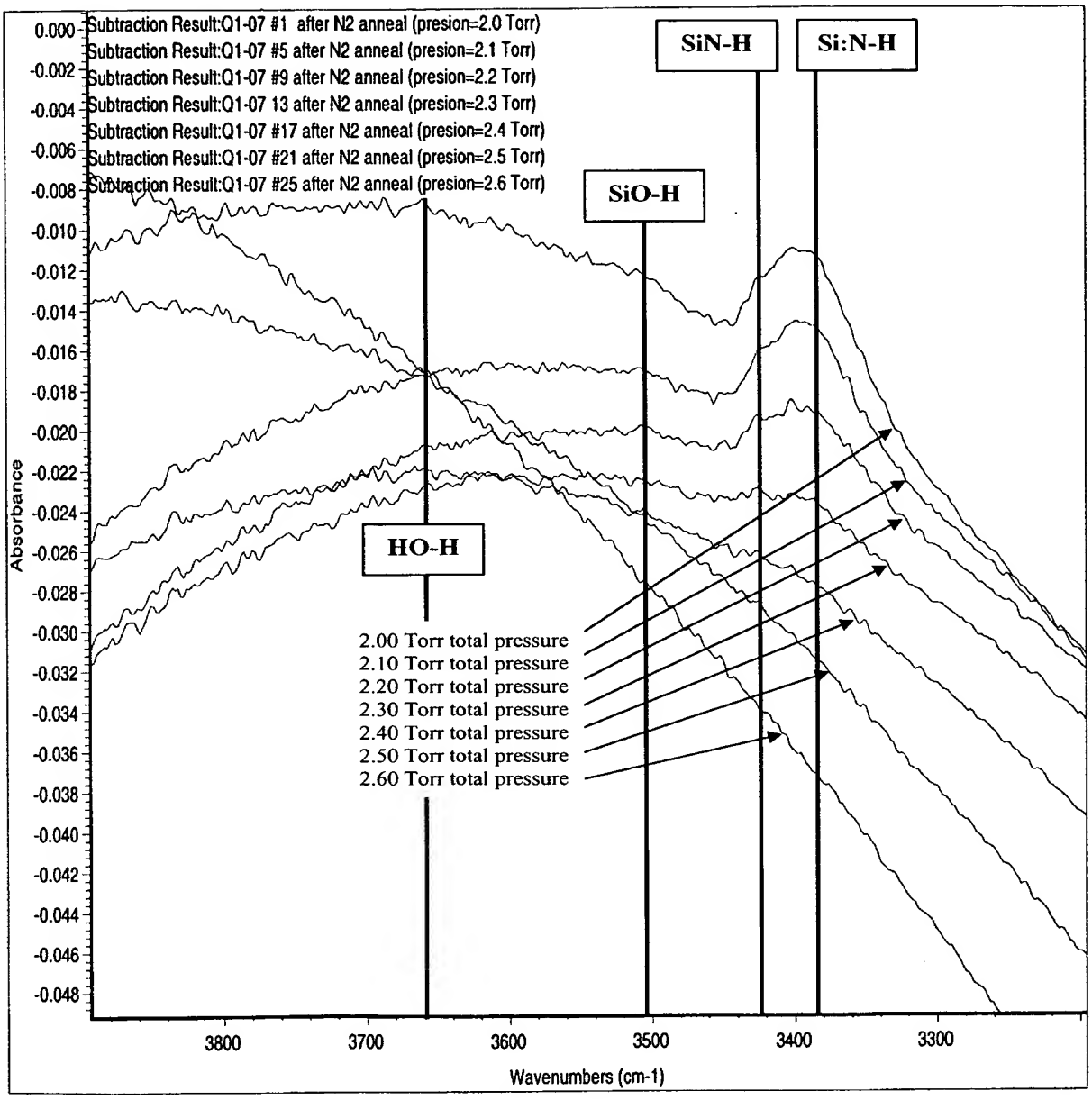

Subtraction Result:Q1-07 #1 after N2 anneal (presion=2.0 Torr)
Subtraction Result:Q1-07 #5 after N2 anneal (presion=2.1 Torr)
Subtraction Result:Q1-07 #9 after N2 anneal (presion=2.2 Torr)
Subtraction Result:Q1-07 13 after N2 anneal (presion=2.3 Torr)
Subtraction Result:Q1-07 #17 after N2 anneal (presion=2.4 Torr)
Subtraction Result:Q1-07 #21 after N2 anneal (presion=2.5 Torr)
Subtraction Result:Q1-07 #25 after N2 anneal (presion=2.6 Torr)
SiN-H
Si:N-H
SiO-H
HO-H
2.00 Torr total pressure
2.10 Torr total pressure
2.20 Torr total pressure
2.30 Torr total pressure
2.40 Torr total pressure
2.50 Torr total pressure
2.60 Torr total pressure
Absorbance
0.000
-0.002
-0.004
-0.006
-0.008
-0.010
-0.012
-0.014
-0.016
-0.018
-0.020
-0.022
-0.024
-0.026
-0.028
-0.030
-0.032
-0.034
-0.036
-0.038
-0.040
-0.042
-0.044
-0.046
-0.048
3800
3700
3600
3500
3400
3300
Wavenumbers (cm-1)

Figure 9c

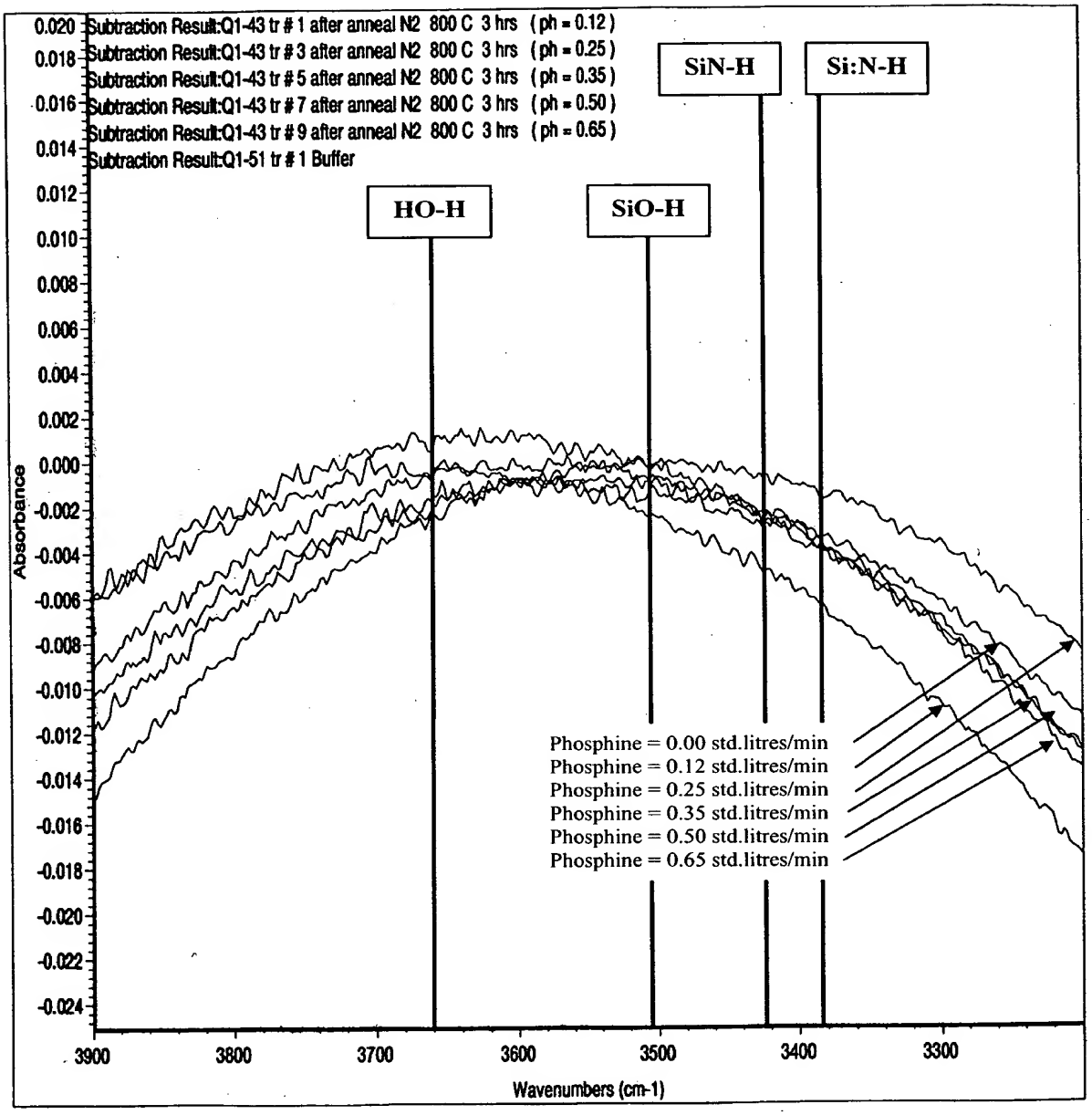

Subtraction Result:Q1-43 tr # 1 after anneal N2 800 C 3 hrs (ph = 0.12)
Subtraction Result:Q1-43 tr # 3 after anneal N2 800 C 3 hrs (ph = 0.25)
Subtraction Result:Q1-43 tr # 5 after anneal N2 800 C 3 hrs (ph = 0.35)
Subtraction Result:Q1-43 tr # 7 after anneal N2 800 C 3 hrs (ph = 0.50)
Subtraction Result:Q1-43 tr # 9 after anneal N2 800 C 3 hrs (ph = 0.65)
Subtraction Result:Q1-51 tr # 1 Buffer
SiN-H
Si:N-H
HO-H
SiO-H
Phosphine = 0.00 std.litres/min
Phosphine = 0.12 std.litres/min
Phosphine = 0.25 std.litres/min
Phosphine = 0.35 std.litres/min
Phosphine = 0.50 std.litres/min
Phosphine = 0.65 std.litres/min
Absorbance
0.020
0.018
0.016
0.014
0.012
0.010
0.008
0.006
0.004
0.002
0.000
-0.002
-0.004
-0.006
-0.008
-0.010
-0.012
-0.014
-0.016
-0.018
-0.020
-0.022
-0.024
3900
3800
3700
3600
3500
3400
3300
Wavenumbers (cm-1)

Figure 9d

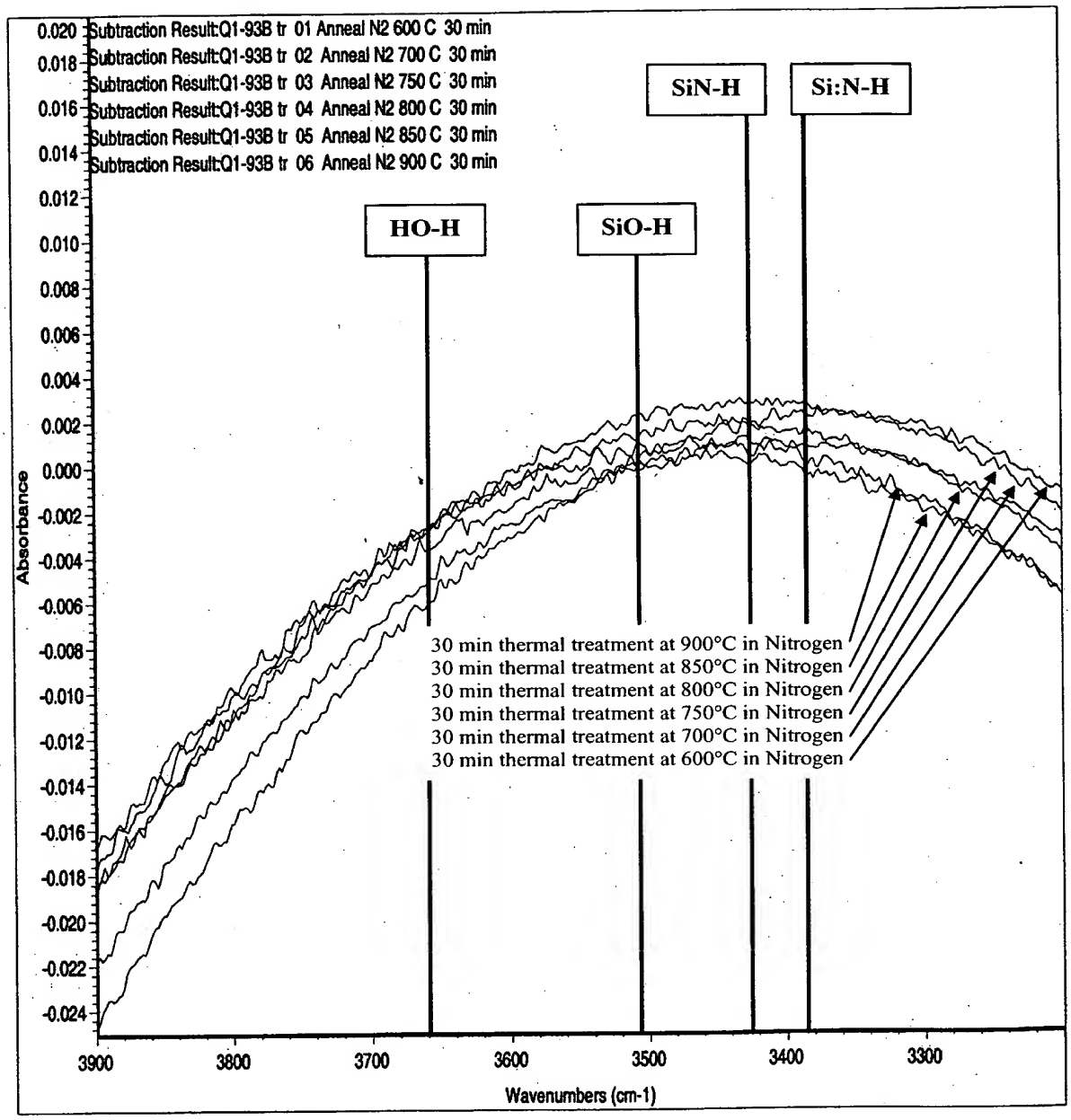
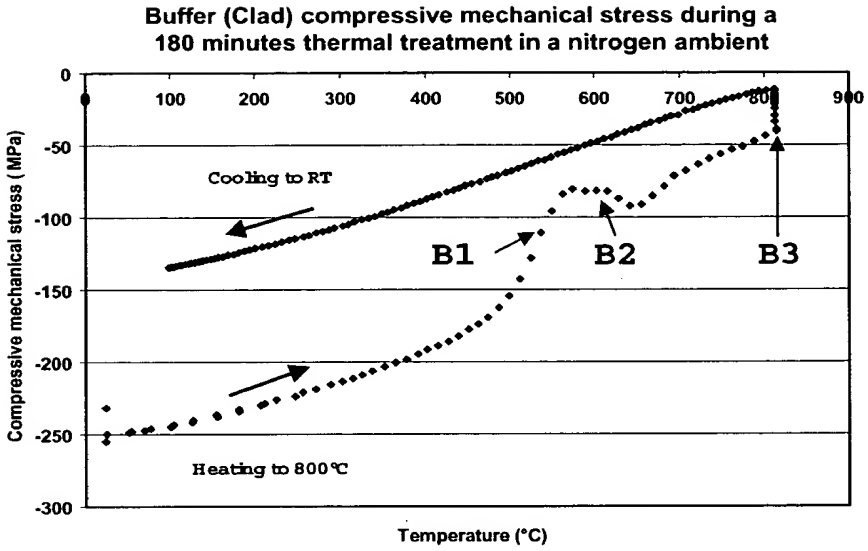

Subtraction Result:Q1-93B tr 01 Anneal N2 600 C 30 min
Subtraction Result:Q1-93B tr 02 Anneal N2 700 C 30 min
Subtraction Result:Q1-93B tr 03 Anneal N2 750 C 30 min
Subtraction Result:Q1-93B tr 04 Anneal N2 800 C 30 min
Subtraction Result:Q1-93B tr 05 Anneal N2 850 C 30 min
Subtraction Result:Q1-93B tr 06 Anneal N2 900 C 30 min
HO-H
SiO-H
SiN-H
Si:N-H
30 min thermal treatment at 900°C in Nitrogen
30 min thermal treatment at 850°C in Nitrogen
30 min thermal treatment at 800°C in Nitrogen
30 min thermal treatment at 750°C in Nitrogen
30 min thermal treatment at 700°C in Nitrogen
30 min thermal treatment at 600°C in Nitrogen
Absorbance
0.020
0.018
0.016
0.014
0.012
0.010
0.008
0.006
0.004
0.002
0.000
-0.002
-0.004
-0.006
-0.008
-0.010
-0.012
-0.014
-0.016
-0.018
-0.020
-0.022
-0.024
3900
3800
3700
3600
3500
3400
3300
Wavenumbers (cm-1)

Figure 10


Buffer (Clad) compressive mechanical stress during a
180 minutes thermal treatment in a nitrogen ambient
Compressive mechanical stress (MPa)
0
-50
-100
-150
-200
-250
-300
100
200
300
400
500
600
700
800
900
Cooling to RT
B1
B2
B3
Heating to 800°C
Temperature (°C)

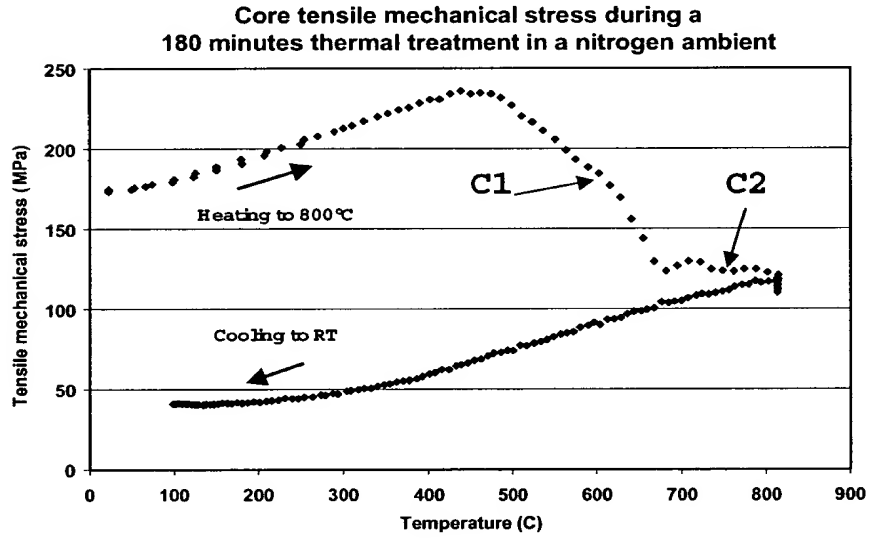

Core tensile mechanical stress during a
180 minutes thermal treatment in a nitrogen ambient
Tensile mechanical stress (MPa)
250
200
150
100
50
0
0
100
200
300
400
500
600
700
800
900
Heating to 800°C
C1
C2
Cooling to RT
Temperature (C)

Figure 11

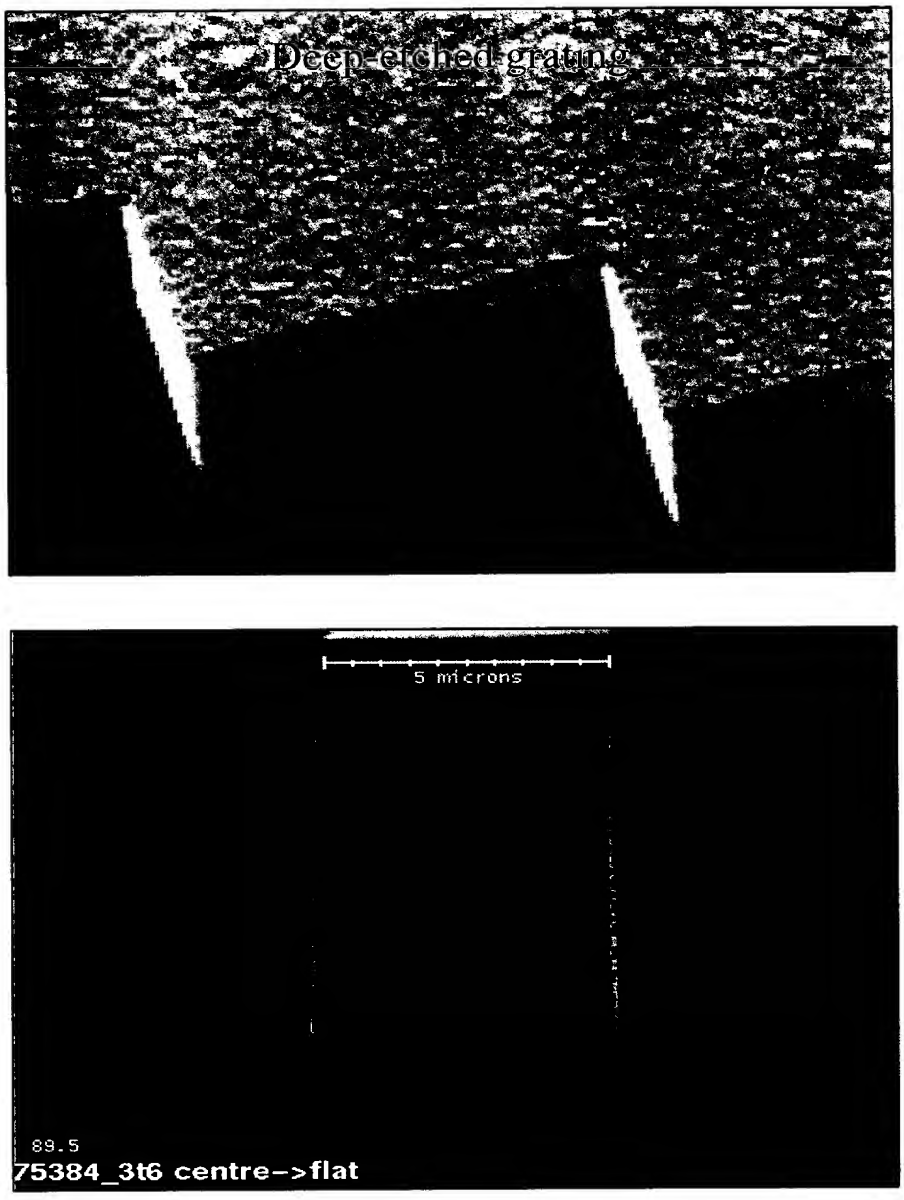


Figure 12

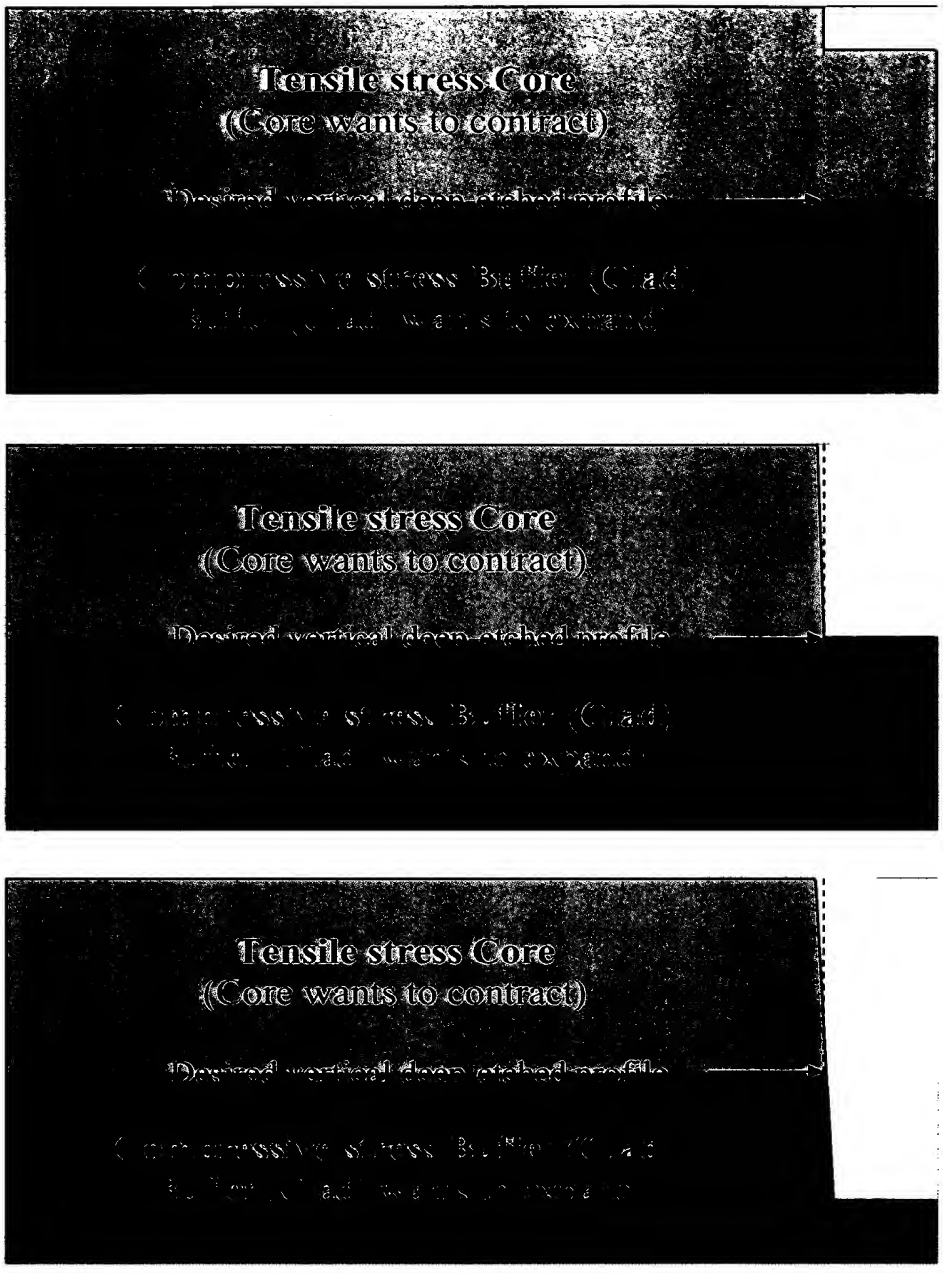
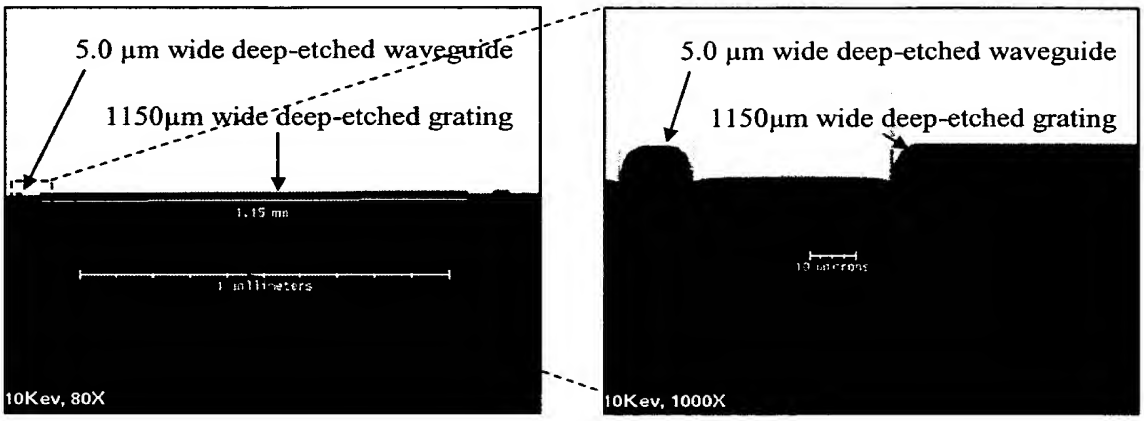
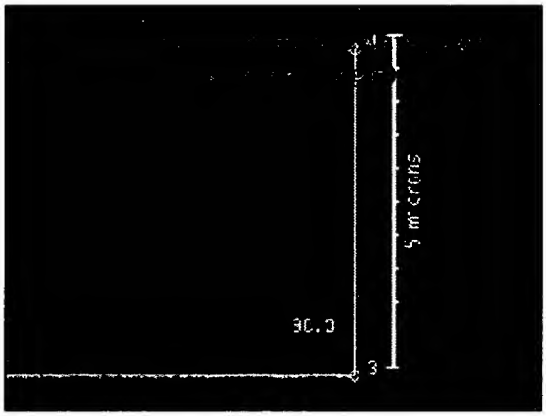

Tensile stress Core
(Core wants to contract)
Tensile stress Core
(Core wants to contract)
Tensile stress Core
(Core wants to contract)

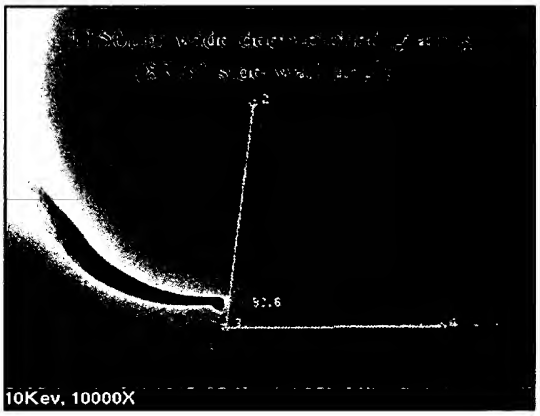
Figure 13



The relative position between an isolated 5.0µm wide deep-etched waveguide and its neighboring 1150µm wide deep-etched grating at two different magnifications.

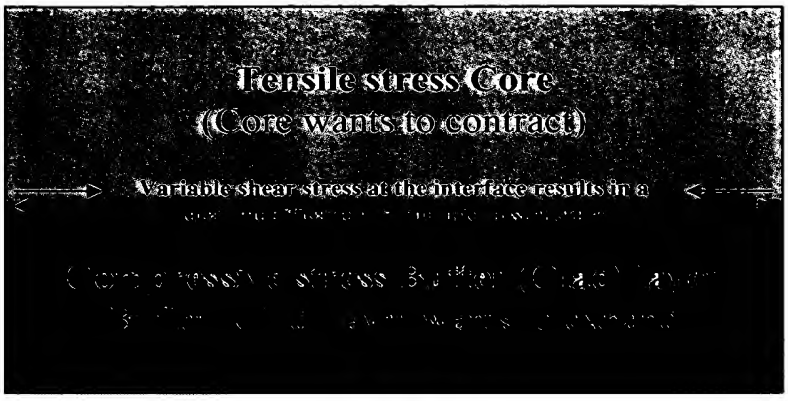


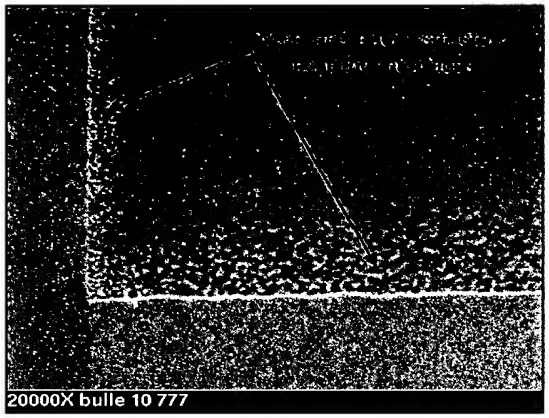
The side-wall of the 5.0µm wide deep-etched waveguide facing the neighboring grating has a slope of about 90°.



The side-wall of the 1150µm wide deep-etched grating facing the neighboring deep-etched waveguide has a much smaller slope of about 84°.

Figure 14


Tensile stress Core
(Core wants to contract)


20000X bulle 10 777

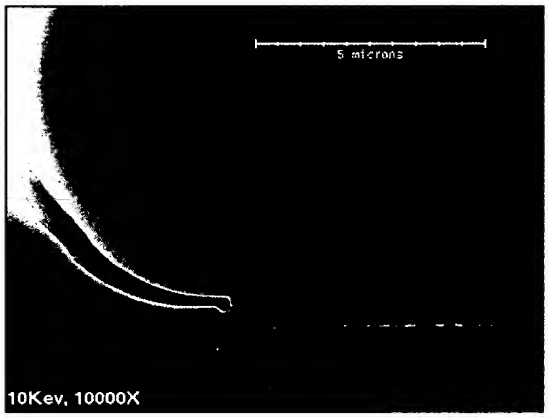

5 microns
10Kev, 10000X

Figure 15

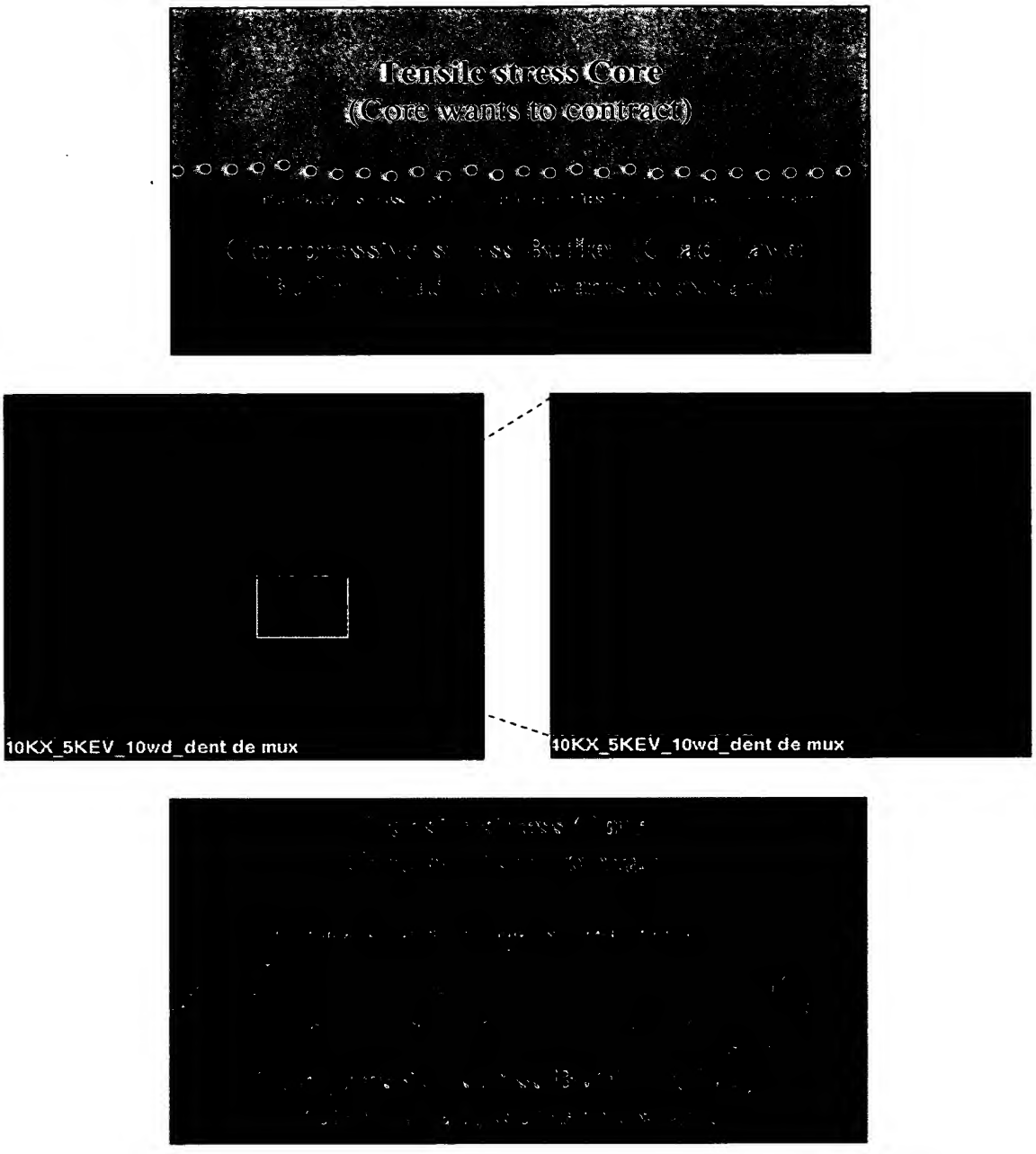

Tensile stress Core
(Core wants to contract)
10KX_5KEV_10wd_dent de mux
10KX_5KEV_10wd_dent de mux

Figure 16

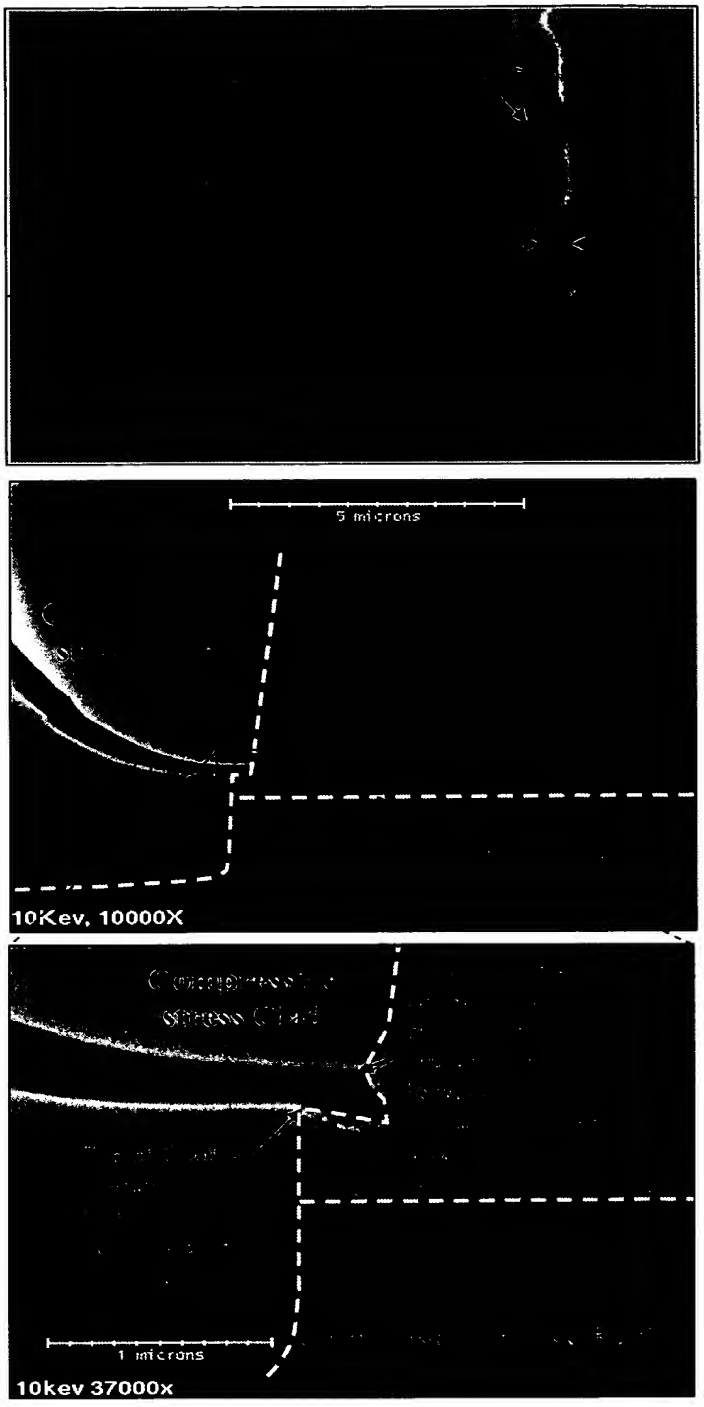


Figure 17

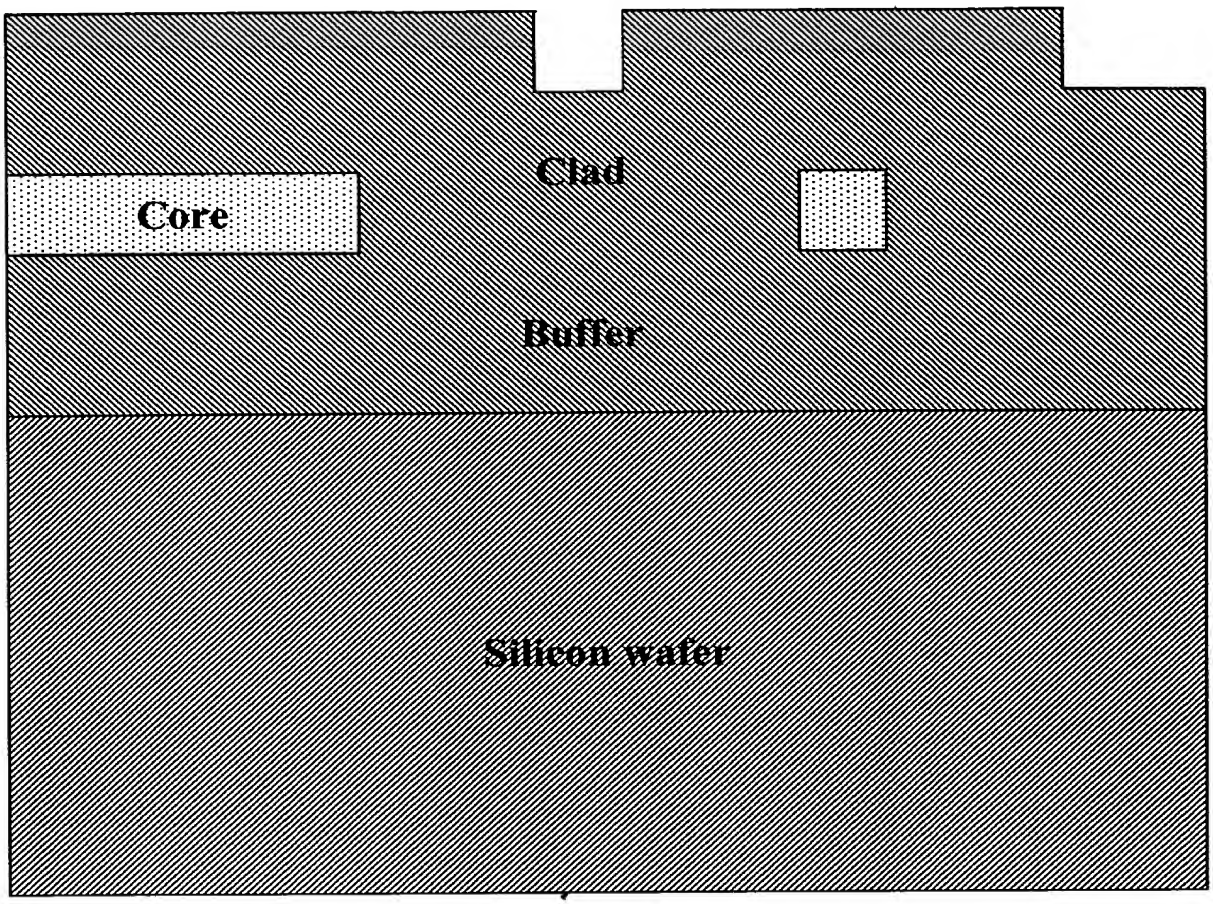


Figure 18a

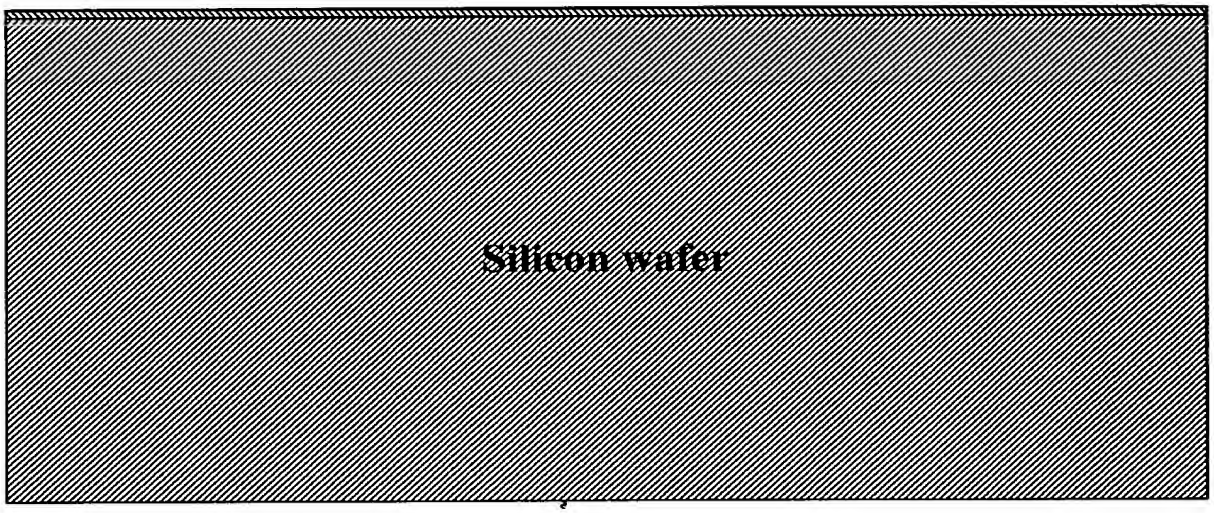


Figure 18b

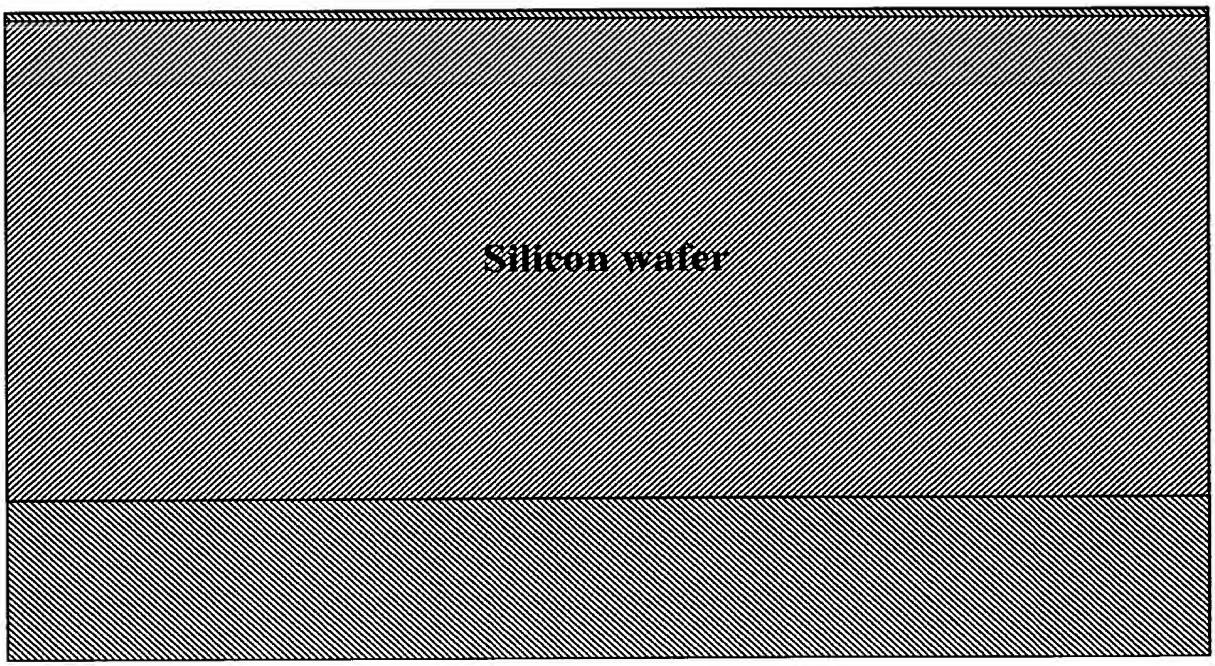


Figure 18c

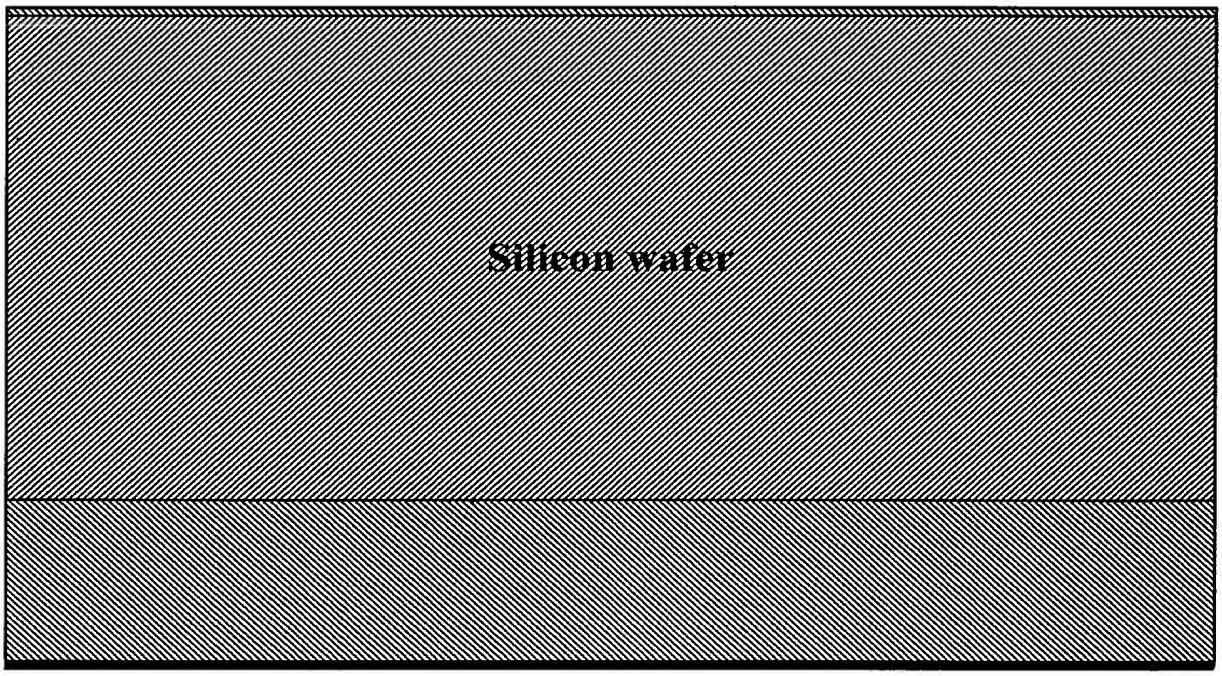


Figure 18d

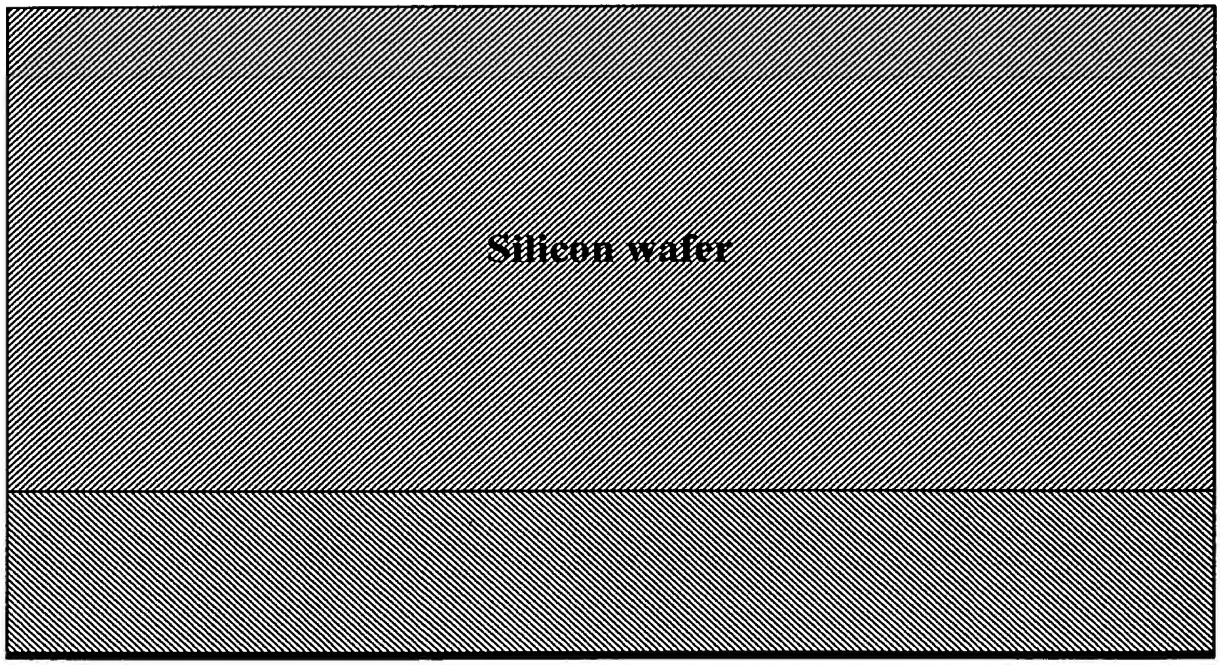


Figure 18e

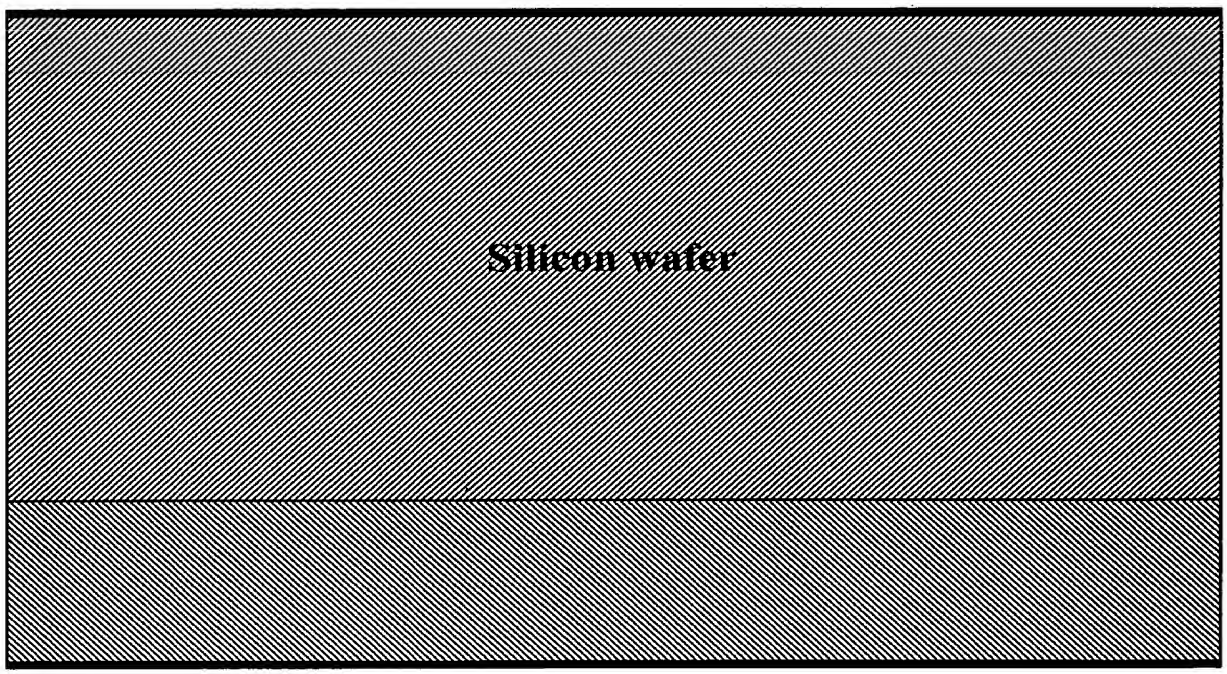


Figure 18f

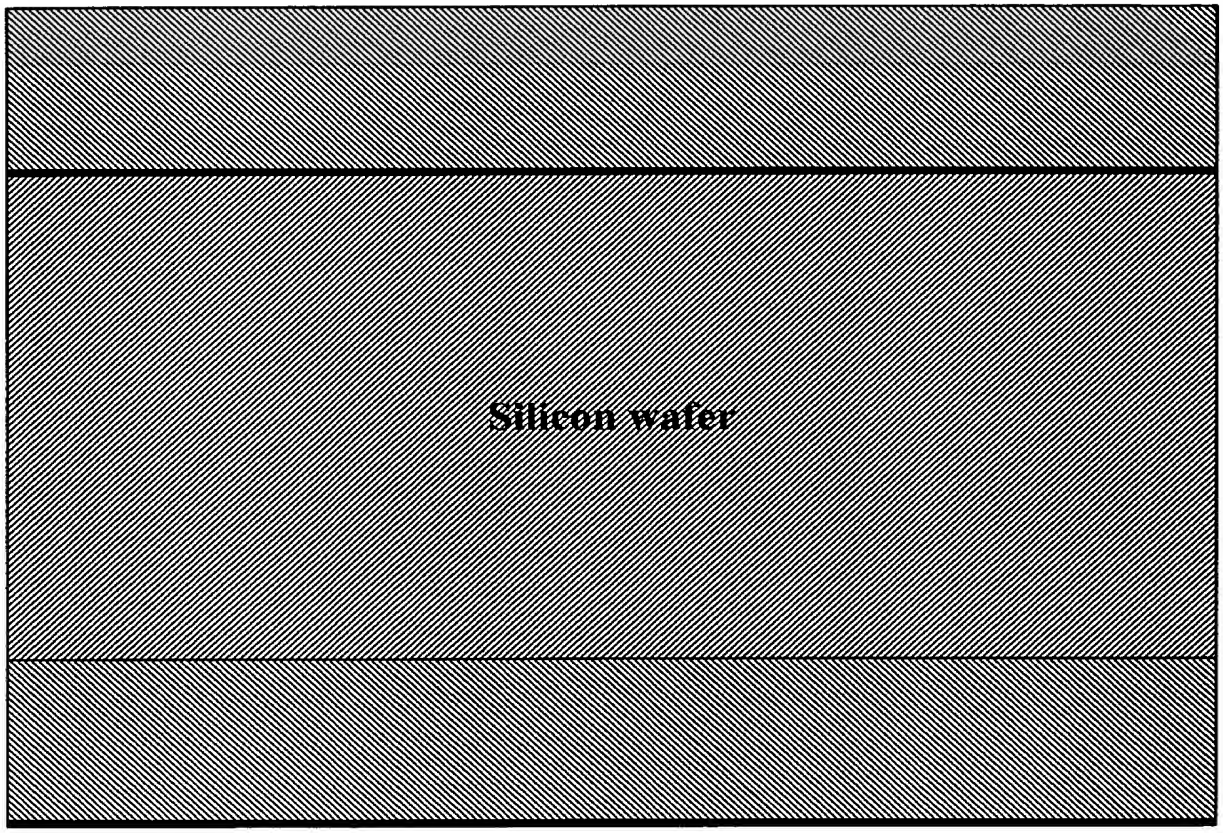


Figure 18g

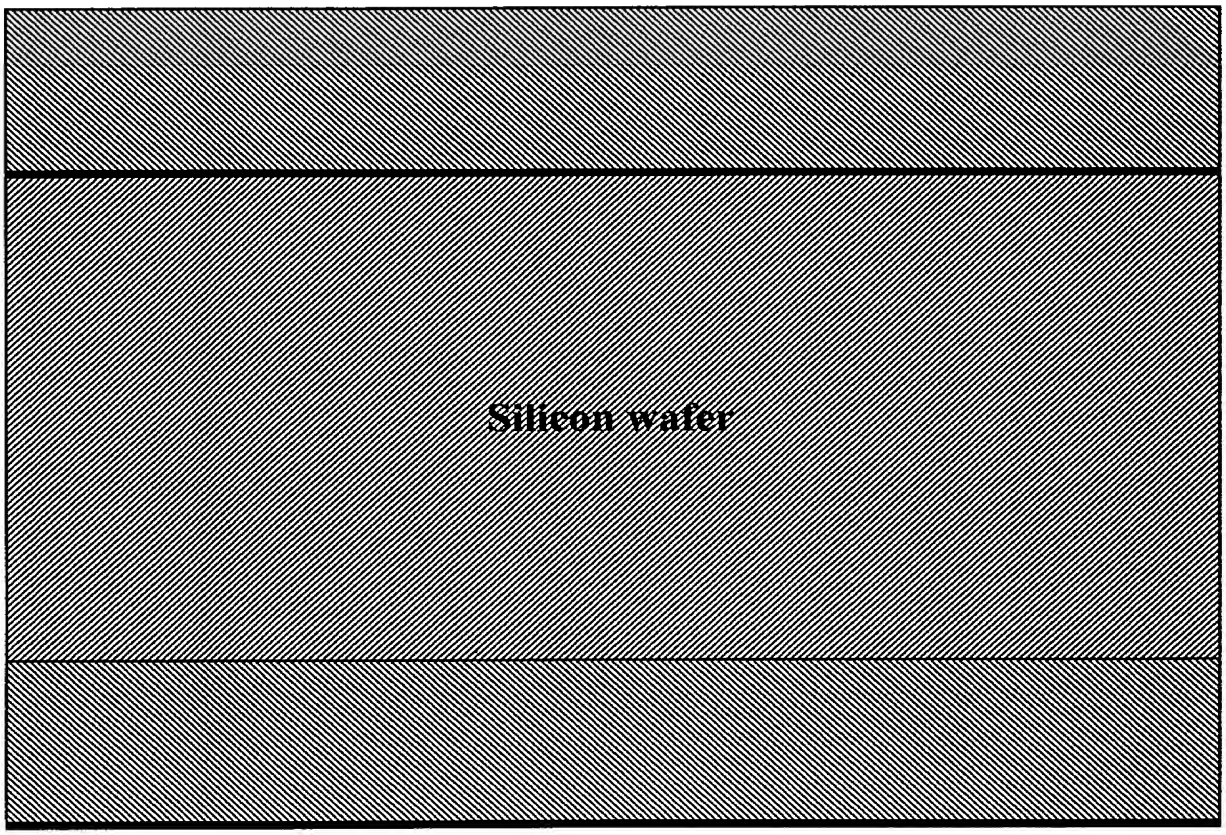


Figure 18h

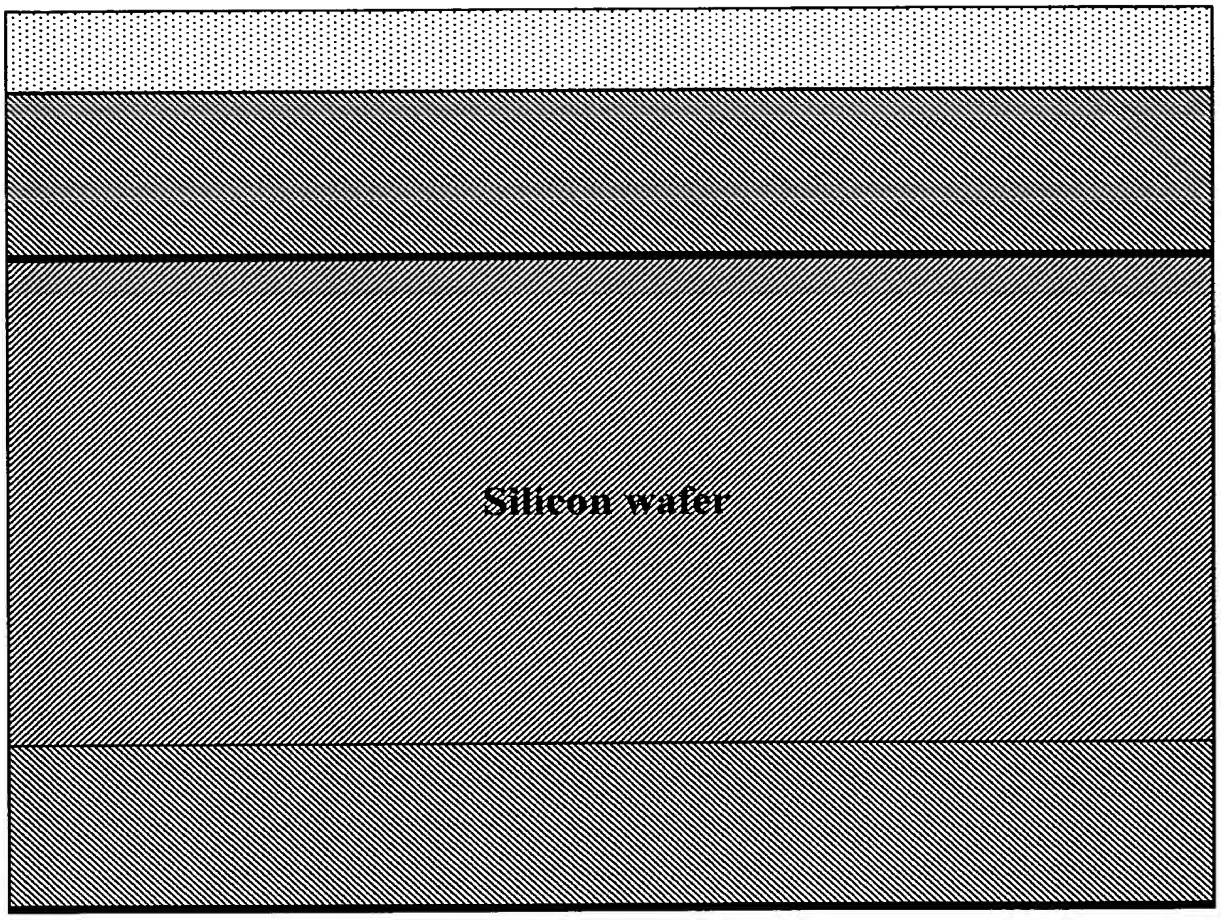


Figure 18i

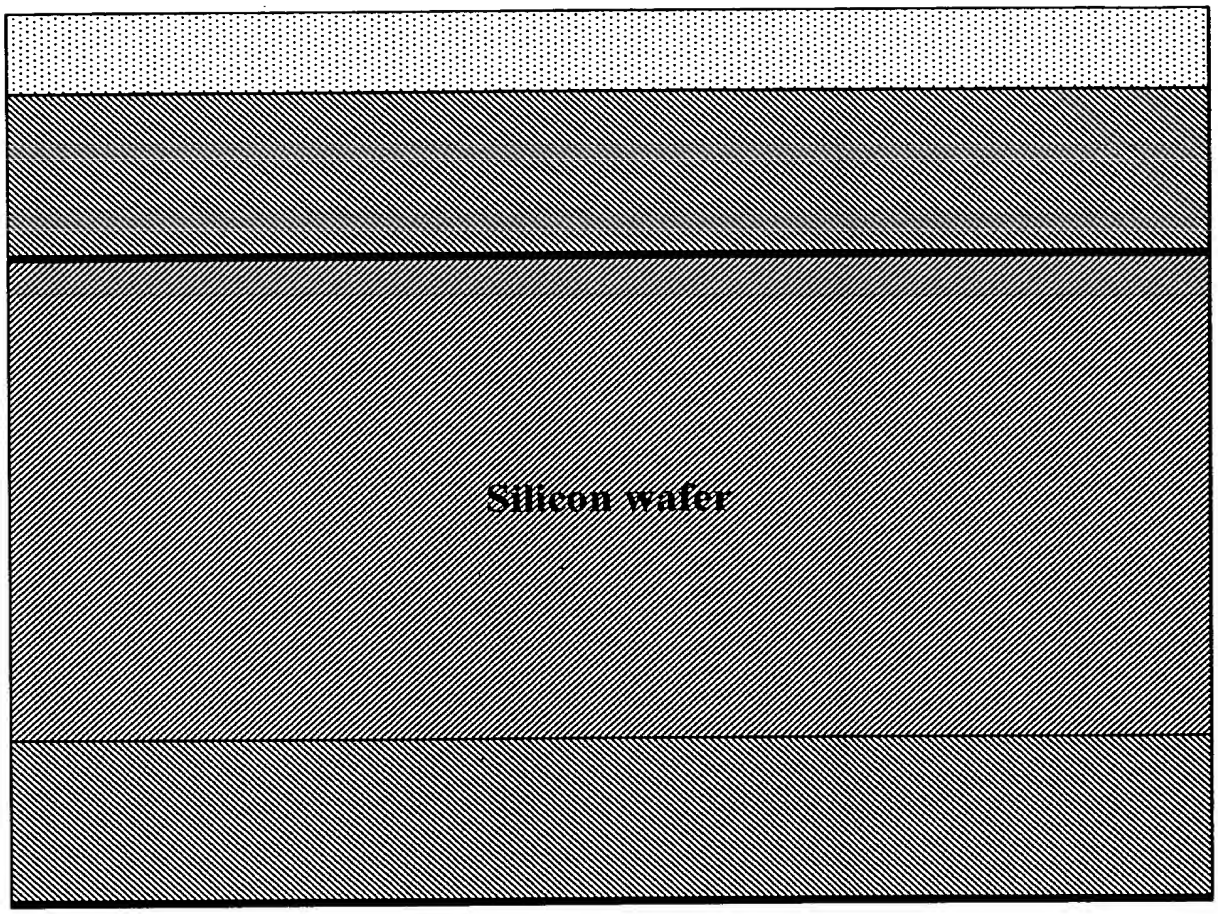


Figure 18l

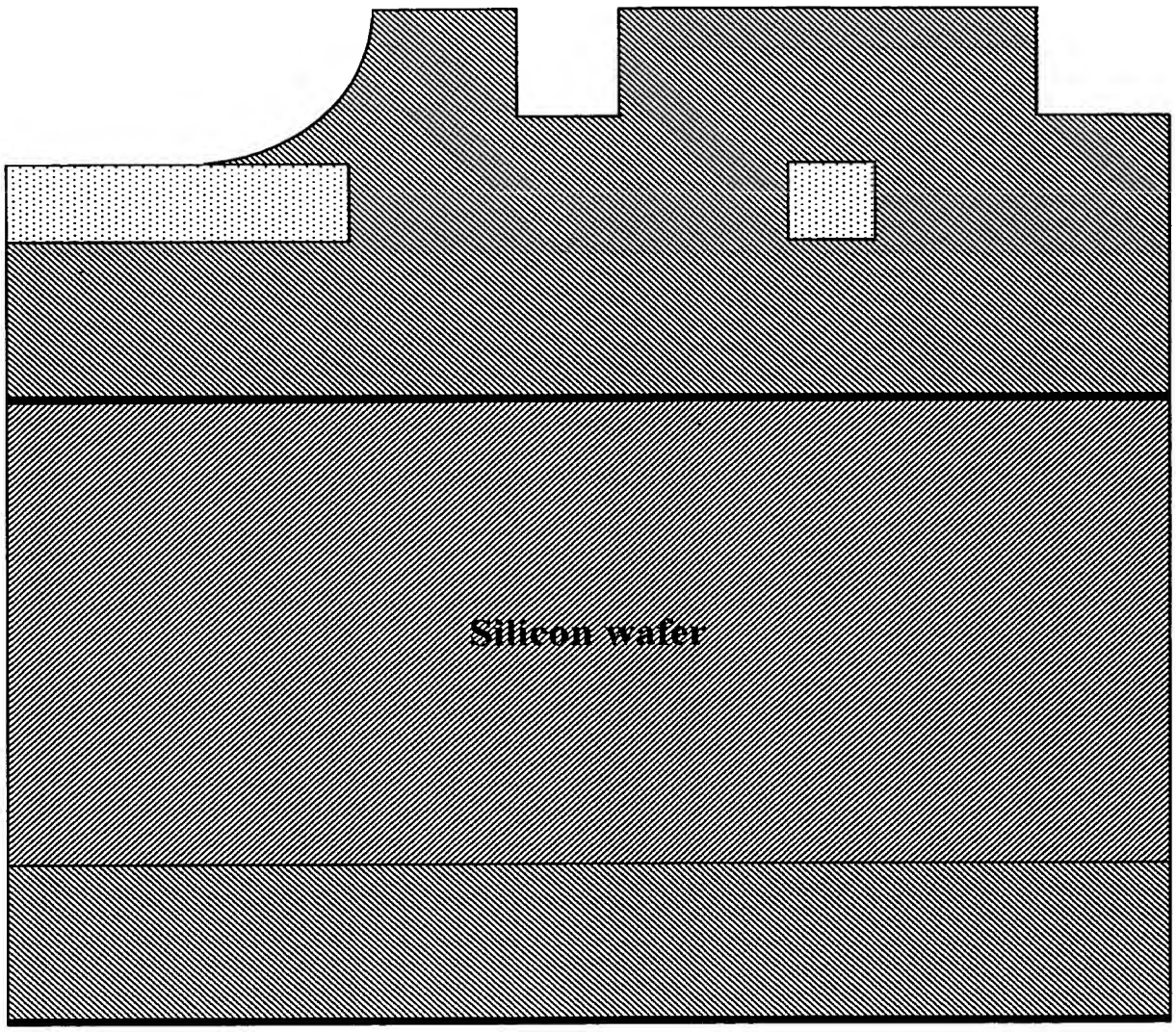


Figure 18j

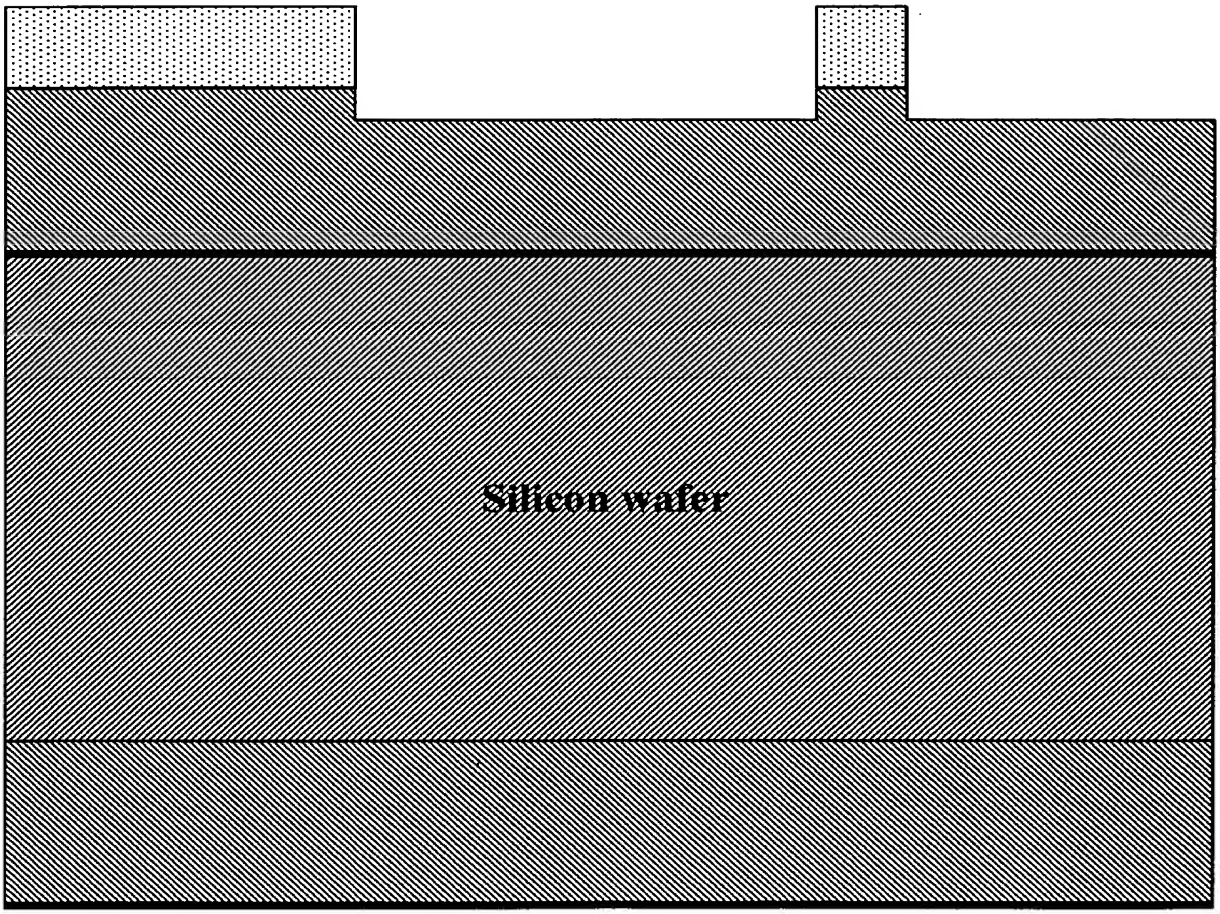


Figure 18k

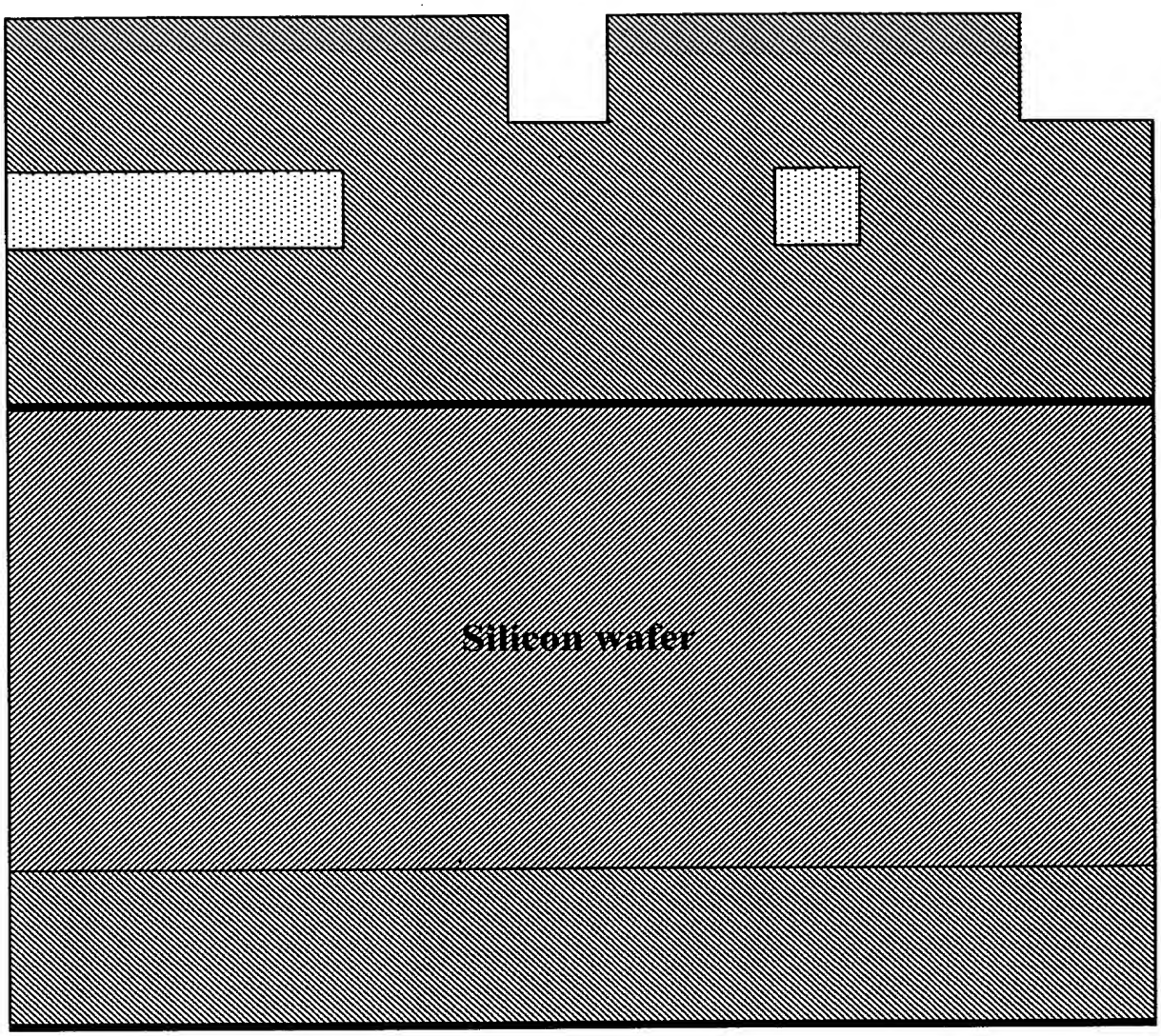


Figure 19

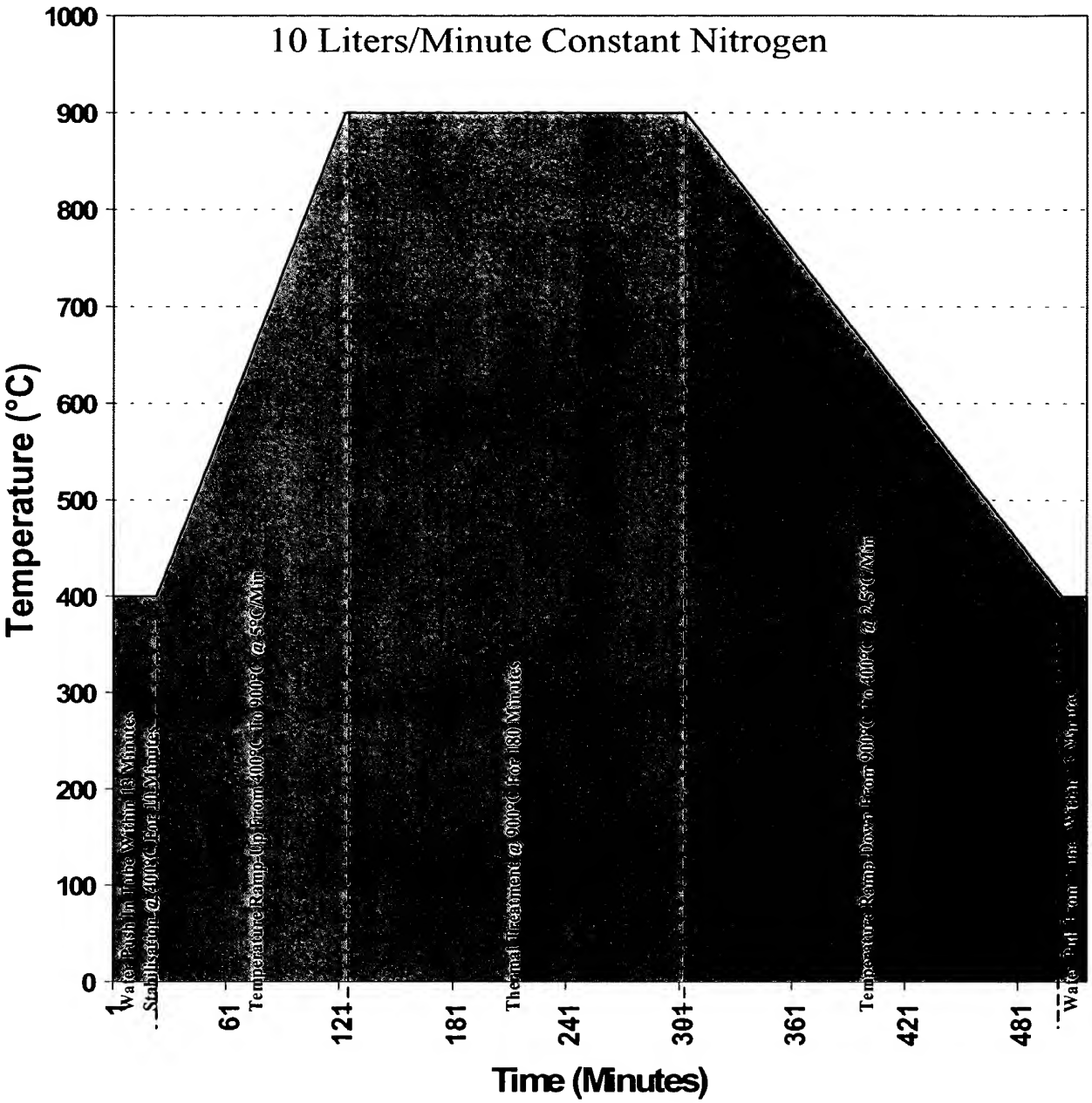

10 Liters/Minute Constant Nitrogen
Temperature (°C)
1000
900
800
700
600
500
400
300
200
100
0
1
61
121
181
241
301
361
421
481
Time (Minutes)
Wafer Push In Tube Within 15 Minutes
Stabilization @ 400°C For 10 Minutes
Temperature Ramp-Up from 400°C To 900°C @ 5°C/Min
Thermal Treatment @ 900°C For 180 Minutes
Temperature Ramp Down From 900°C To 400°C @ 2.5°C/Min

Figure 20

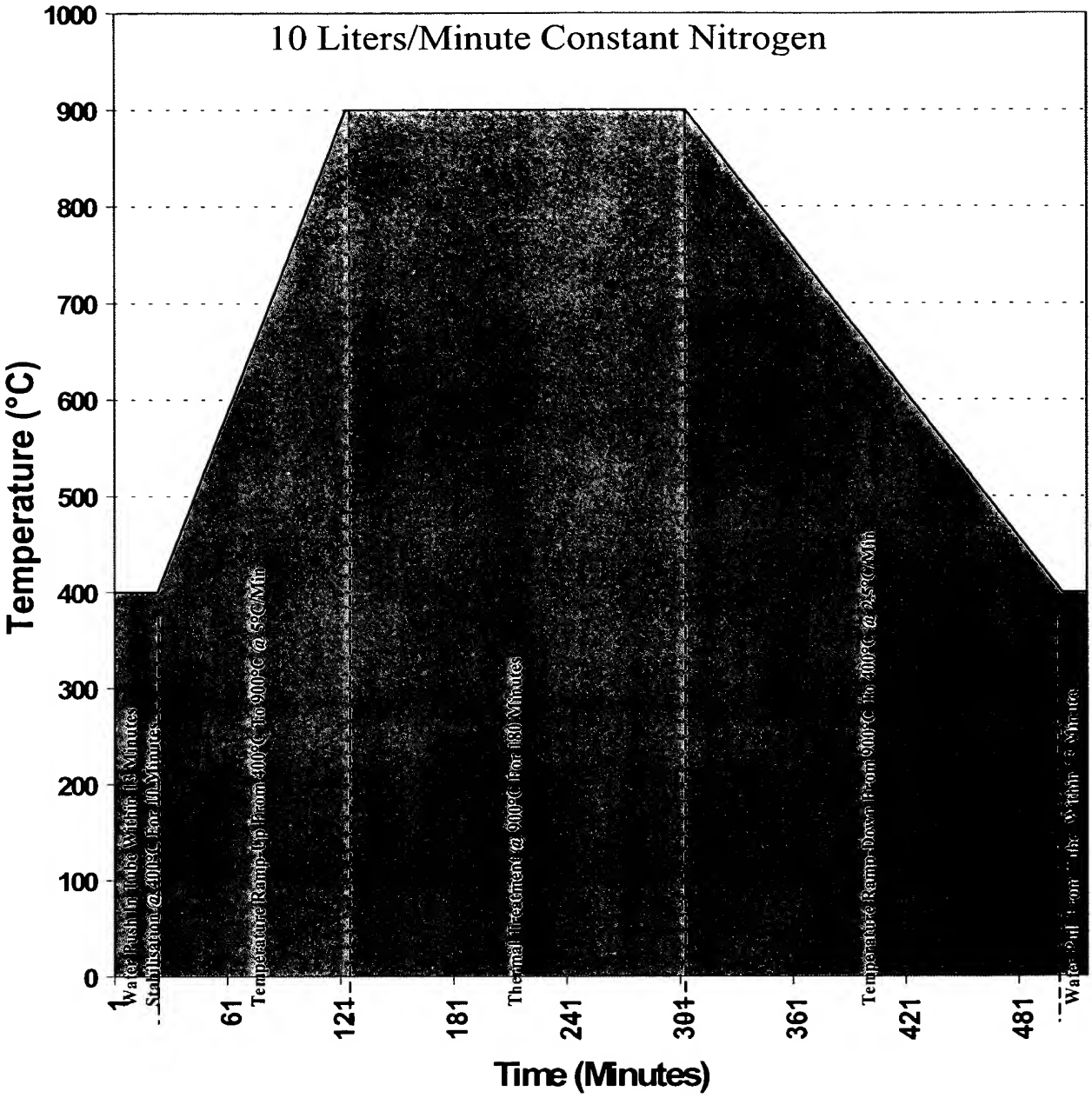

10 Liters/Minute Constant Nitrogen
Temperature (°C)
1000
900
800
700
600
500
400
300
200
100
0
1
61
121
181
241
304
361
421
481
Time (Minutes)
Wafer Push In Tube Within 13 Minutes
Stabilization @ 400°C for 10 Minutes
Temperature Ramp-Up From 400°C To 900°C @ 5°C/Min
Thermal Treatment @ 900°C For 180 Minutes
Temperature Ramp-Down From 900°C To 400°C @ 2.5°C/Min

Figure 21

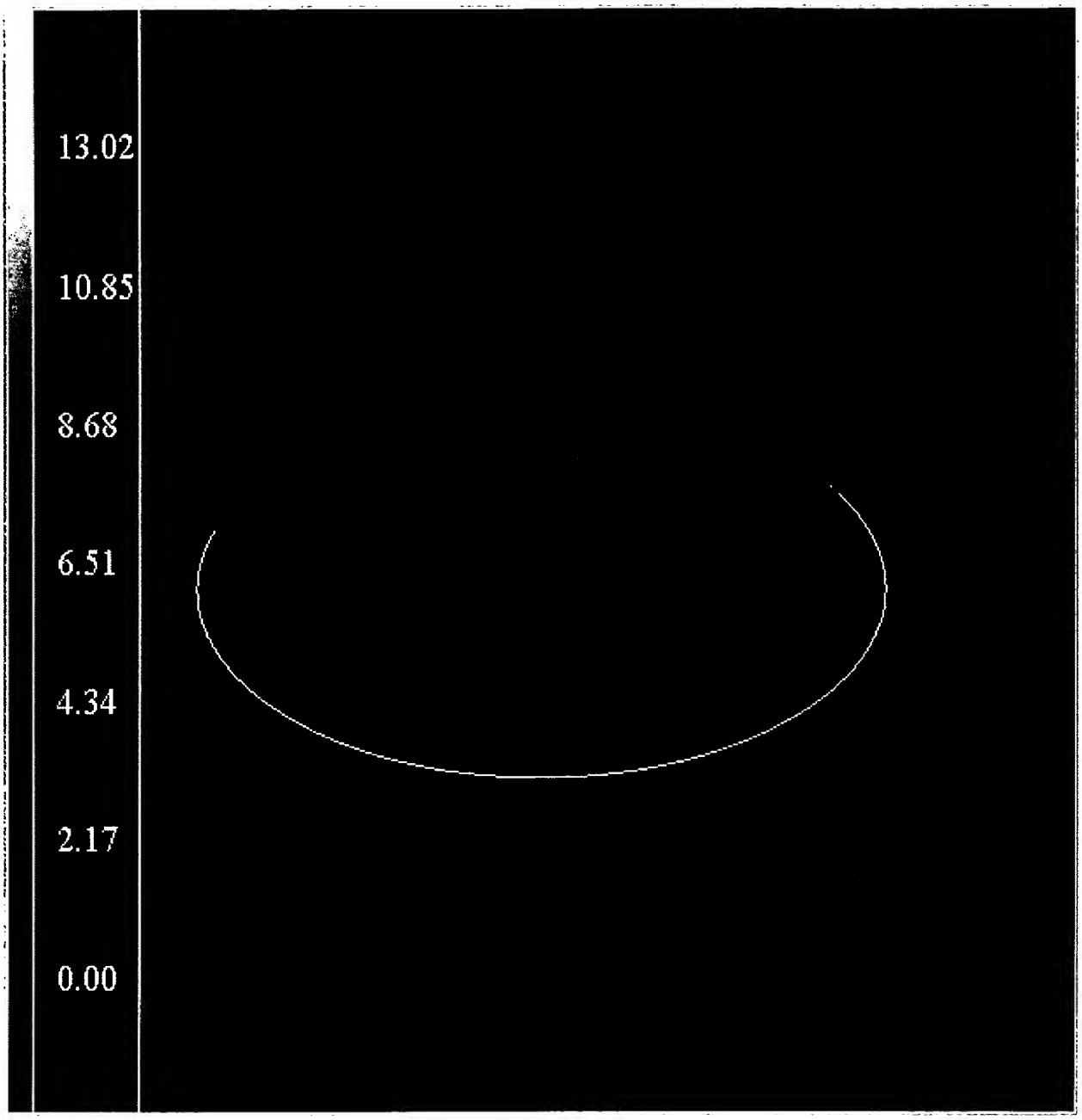


Figure 22

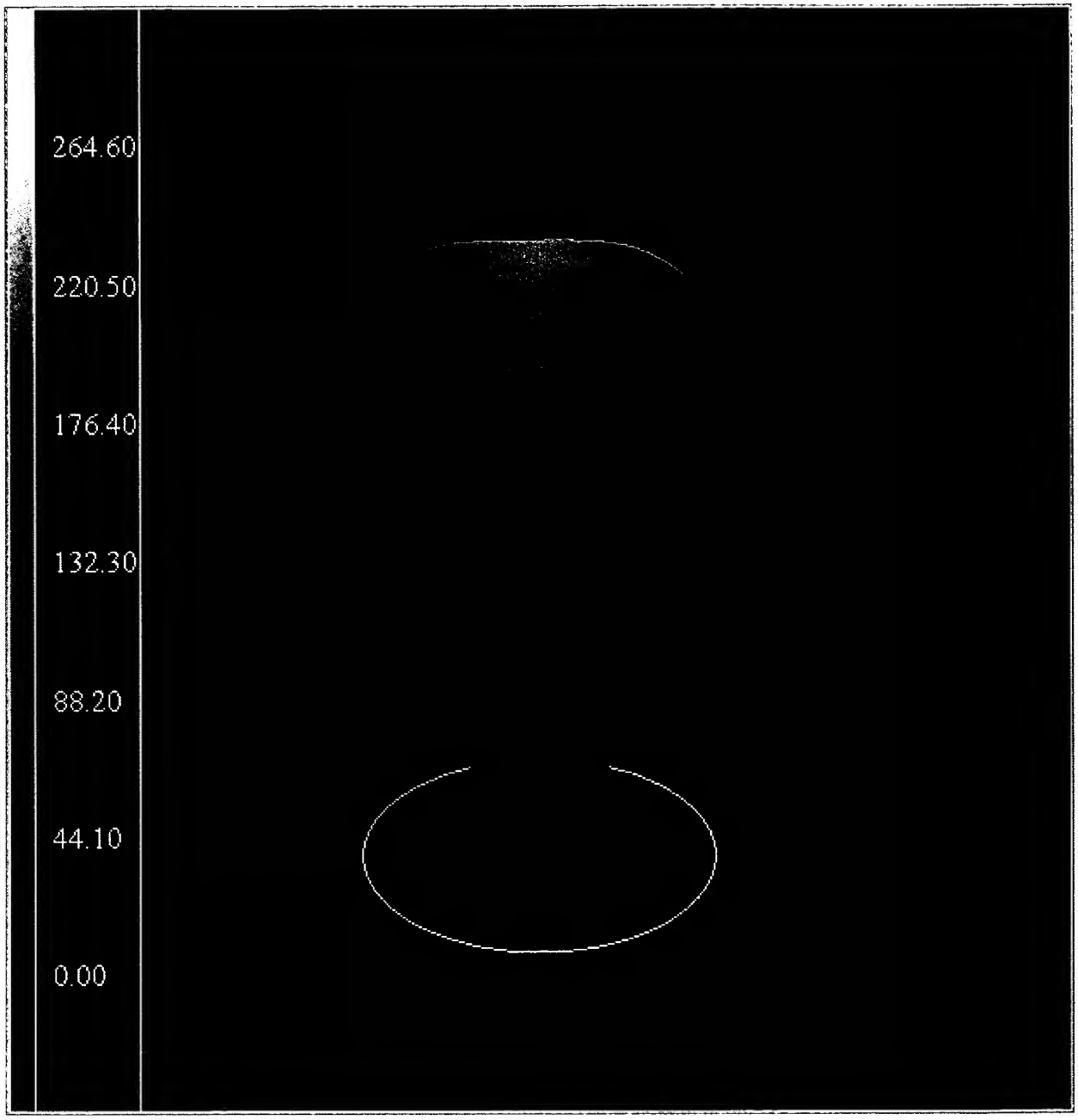


Figure 23